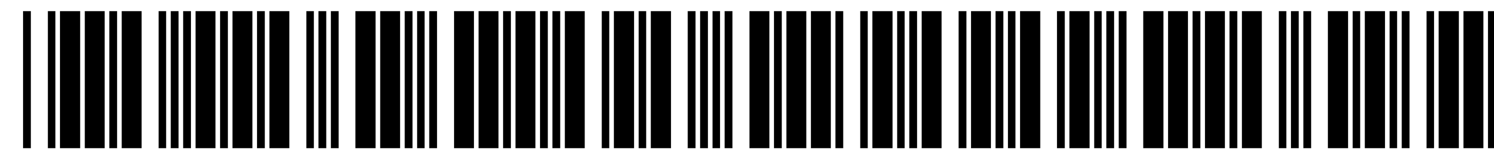


(19) **United States**
(12) **Reissued Patent**
Tanaka

(10) **Patent Number: US RE48,990 E**
(45) **Date of Reissued Patent: Mar. 29, 2022**

(54) **LIQUID EJECTION APPARATUS AND METHOD OF FORMING LIQUID EJECTION APPARATUS**

(71) Applicant: **BROTHER KOGYO KABUSHIKI KAISHA**, Nagoya (JP)

(72) Inventor: **Taiki Tanaka**, Nagoya (JP)

(73) Assignee: **BROTHER KOGYO KABUSHIKI KAISHA**, Nagoya (JP)

(21) Appl. No.: **16/444,009**

(22) Filed: **Jun. 18, 2019**

Related U.S. Patent Documents

Reissue of:

(64) Patent No.: **9,682,558**
Issued: **Jun. 20, 2017**
Appl. No.: **14/969,701**
Filed: **Dec. 15, 2015**

(30) **Foreign Application Priority Data**

Dec. 26, 2014 (JP) 2014-264177

(51) **Int. Cl.**
B41J 2/14 (2006.01)
B41J 2/16 (2006.01)

(52) **U.S. Cl.**
CPC ***B41J 2/14233*** (2013.01); ***B41J 2/161*** (2013.01); ***B41J 2/1623*** (2013.01); ***B41J 2/1628*** (2013.01);

(Continued)

(58) **Field of Classification Search**
None
See application file for complete search history.

(56) **References Cited**

U.S. PATENT DOCUMENTS

6,450,617 B1 * 9/2002 Kitani B41J 2/14072 347/50
9,356,222 B2 * 5/2016 Sakai H01L 41/053

(Continued)

FOREIGN PATENT DOCUMENTS

CN 1346828 A2 9/2003
CN 101388432 A 3/2009

(Continued)

OTHER PUBLICATIONS

Machine Translation of JP 2013-247221 (annotated) , Clarivate Analytics, 2021, 7 pages. (Year: 2021).*

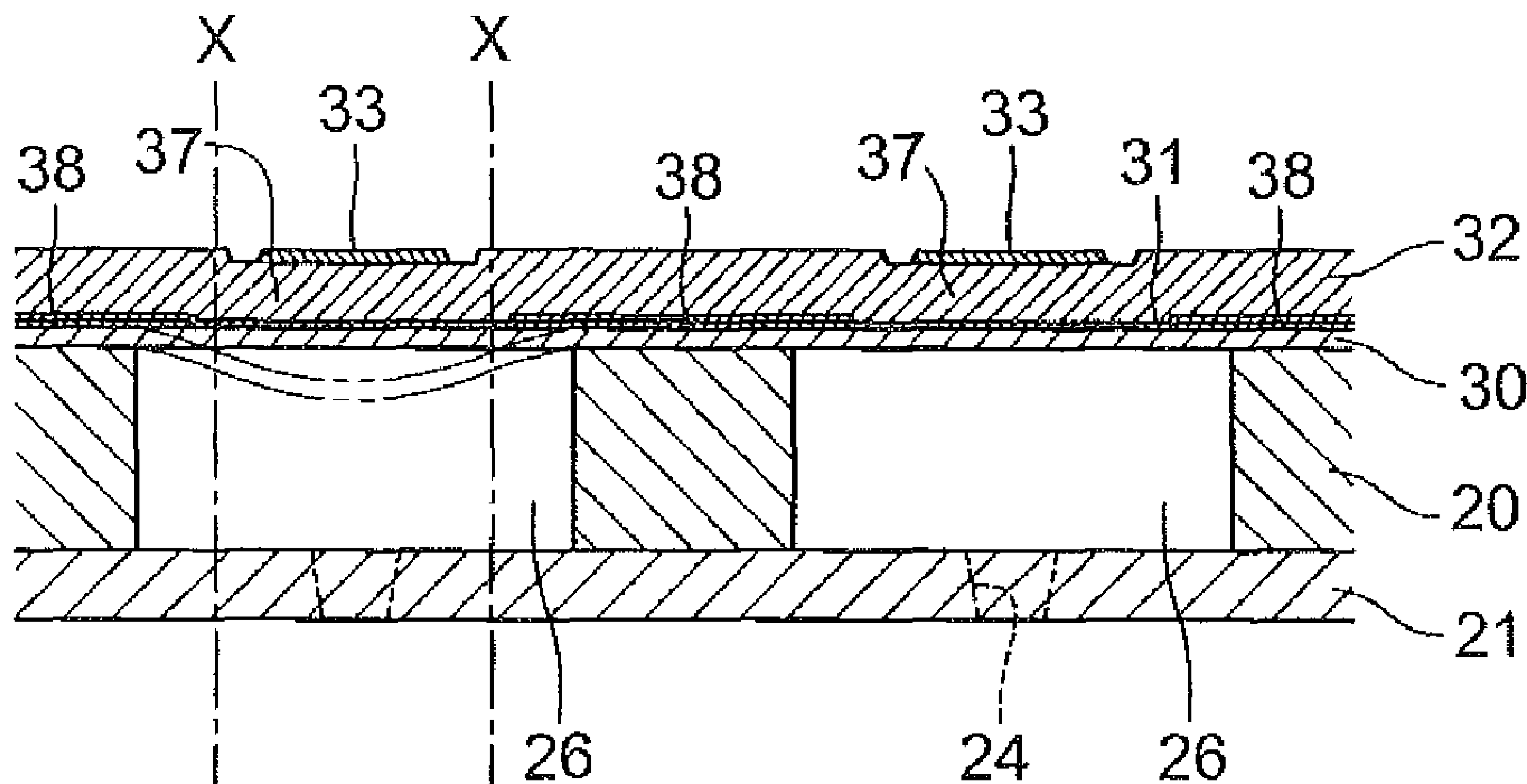
(Continued)

Primary Examiner — Sean E Vincent
(74) *Attorney, Agent, or Firm* — Merchant & Gould P.C.

(57) **ABSTRACT**

A liquid ejection apparatus and method of manufacture are disclosed. One apparatus includes a pressure chamber, a diaphragm covering the pressure chamber, and a piezoelectric element having a piezoelectric component positioned opposing the pressure chamber. The apparatus further includes a first electrode disposed on a first side of the piezoelectric component toward the pressure chamber and a second electrode disposed on a second side of the piezoelectric component opposite the first side in an opposed region, the opposed region being a region opposed to the second electrode. The apparatus also includes a metal film disposed between the piezoelectric component and the diaphragm, the metal film being absent from at least a portion of the opposed region. The metal film and the first electrode are in electrical contact with each other. The first electrode is made of platinum and the metal film is made of a metal material other than platinum.

15 Claims, 14 Drawing Sheets



(52) **U.S. Cl.**
CPC ***B41J 2/1646*** (2013.01); *B41J 2002/14266* (2013.01); *B41J 2002/14491* (2013.01)

(56) **References Cited**

U.S. PATENT DOCUMENTS

2009/0066763	A1	3/2009	Fujii et al.
2009/0309936	A1	12/2009	Mita
2014/0240398	A1	8/2014	Yamashita
2015/0085023	A1	3/2015	Sakai

FOREIGN PATENT DOCUMENTS

CN	104002558	A	8/2014
EP	1346828	A2	9/2003
JP	2000-006398	A	1/2000
JP	4811598	B2	11/2011
JP	2013-247221	A	12/2013
JP	2016-27593	A	2/2016

OTHER PUBLICATIONS

Notice of Reasons for Refusal issued in related Japanese Patent Application No. 2014-264177, dated Jul. 25, 2019.
First Office Action from corresponding Chinese Patent Application No. 201511001068.2, dated Dec. 13, 2016, 20 pages.

* cited by examiner

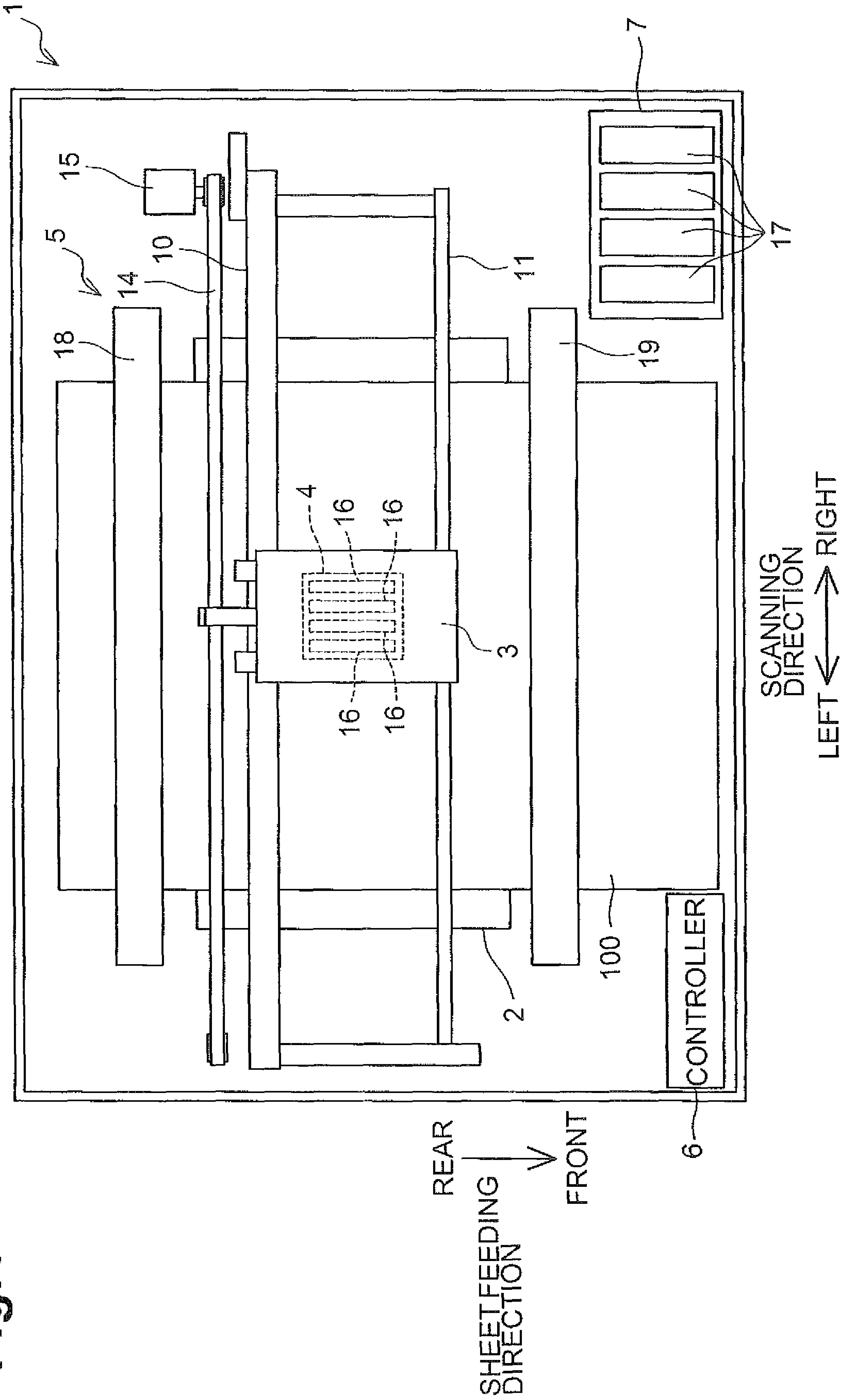


Fig.1
1
5
7
15
10
14
11
17
18
19
4
16
16
16
16
3
2
100
CONTROLLER
6
SCANNING DIRECTION
LEFT
RIGHT
SHEET FEEDING DIRECTION
REAR
FRONT

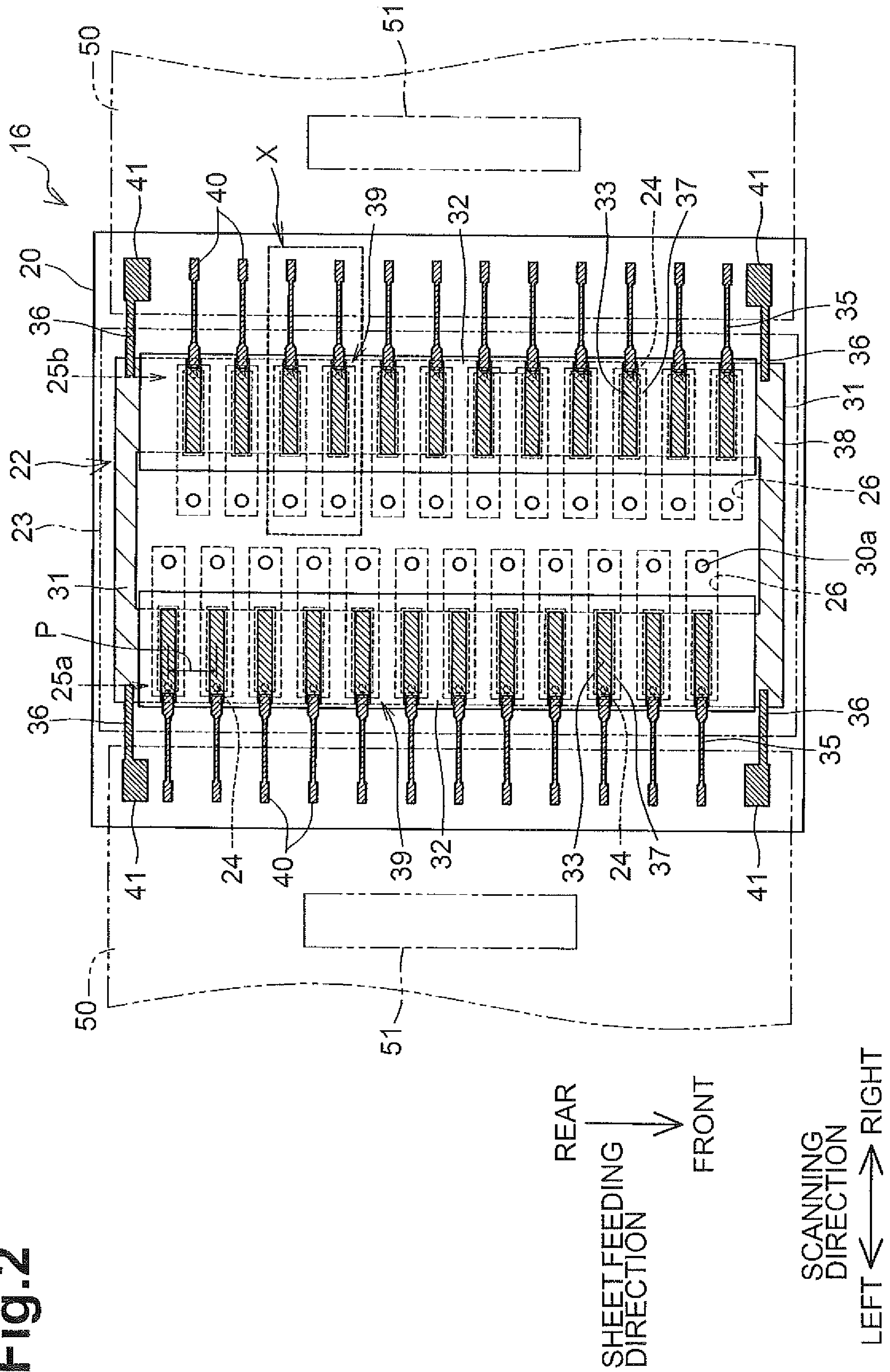


Fig.2
16
20
22
23
25a
25b
26
30a
31
32
33
35
36
37
38
39
40
41
50
51
X
P
24
SHEET FEEDING DIRECTION
REAR
FRONT
SCANNING DIRECTION
LEFT
RIGHT

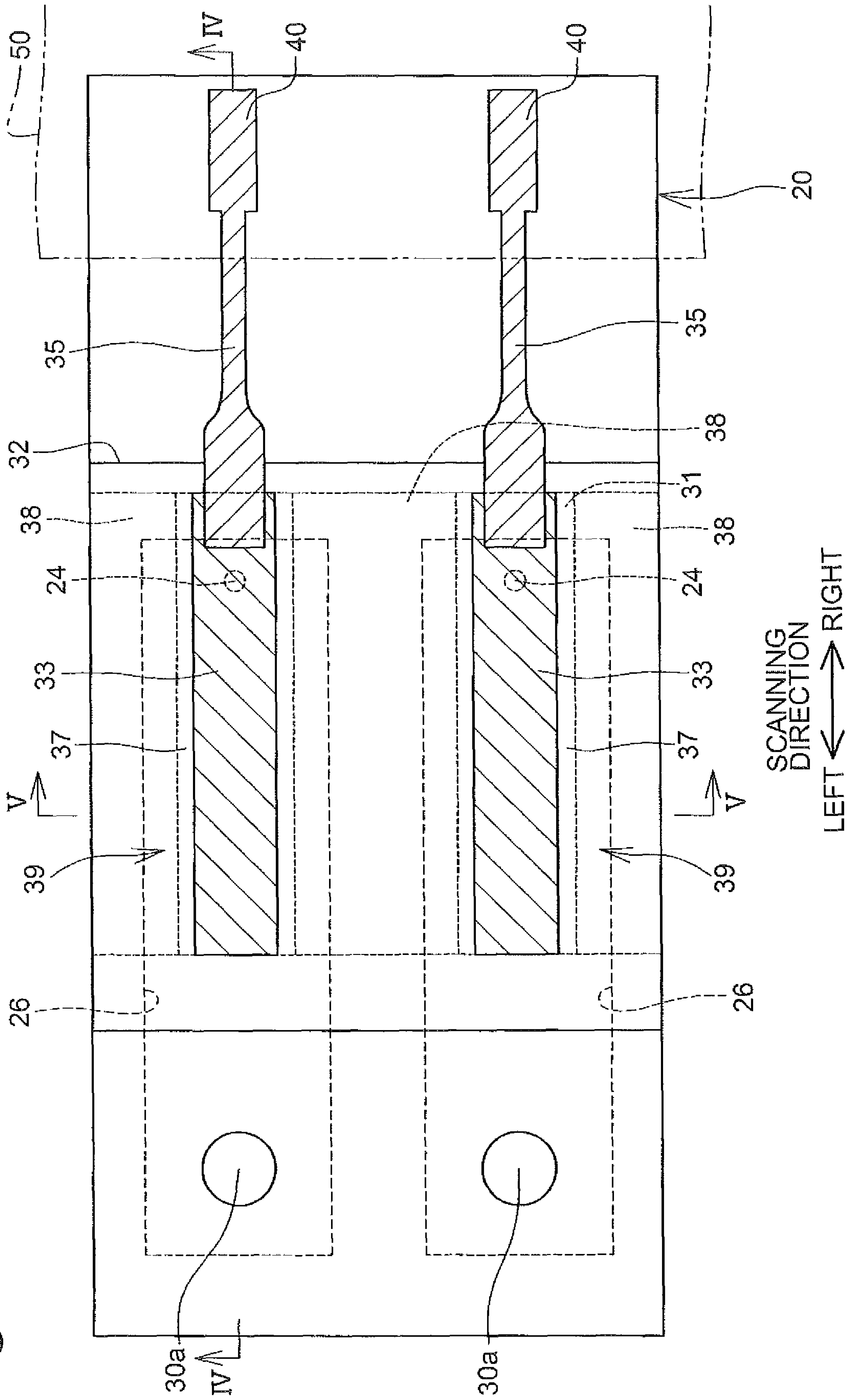


Fig.3
50
IV
40
40
20
35
35
38
32
31
38
38
24
24
33
33
37
37
V
V
39
39
26
26
30a
30a
IV
SCANNING DIRECTION
LEFT
RIGHT

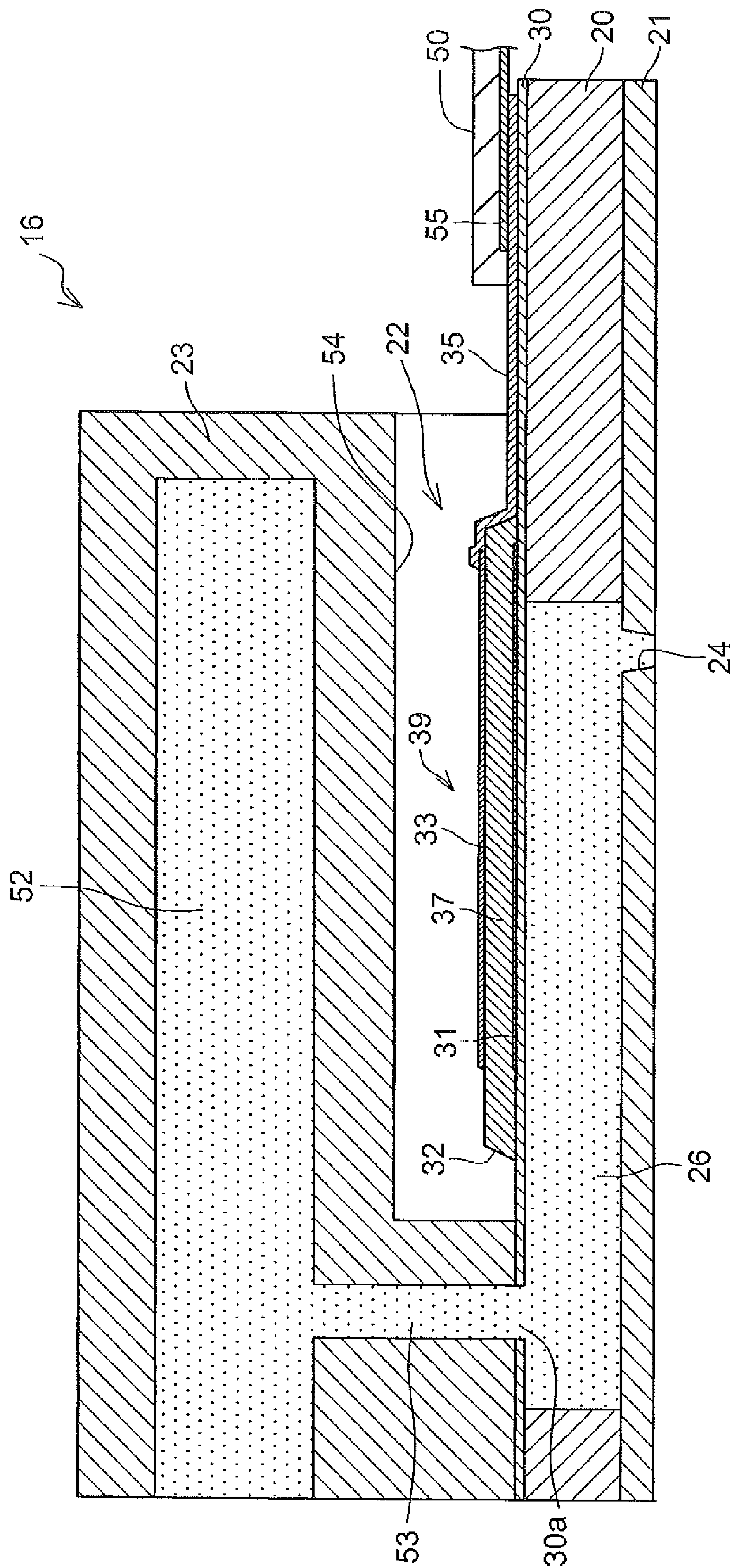


Fig.4

Fig.5

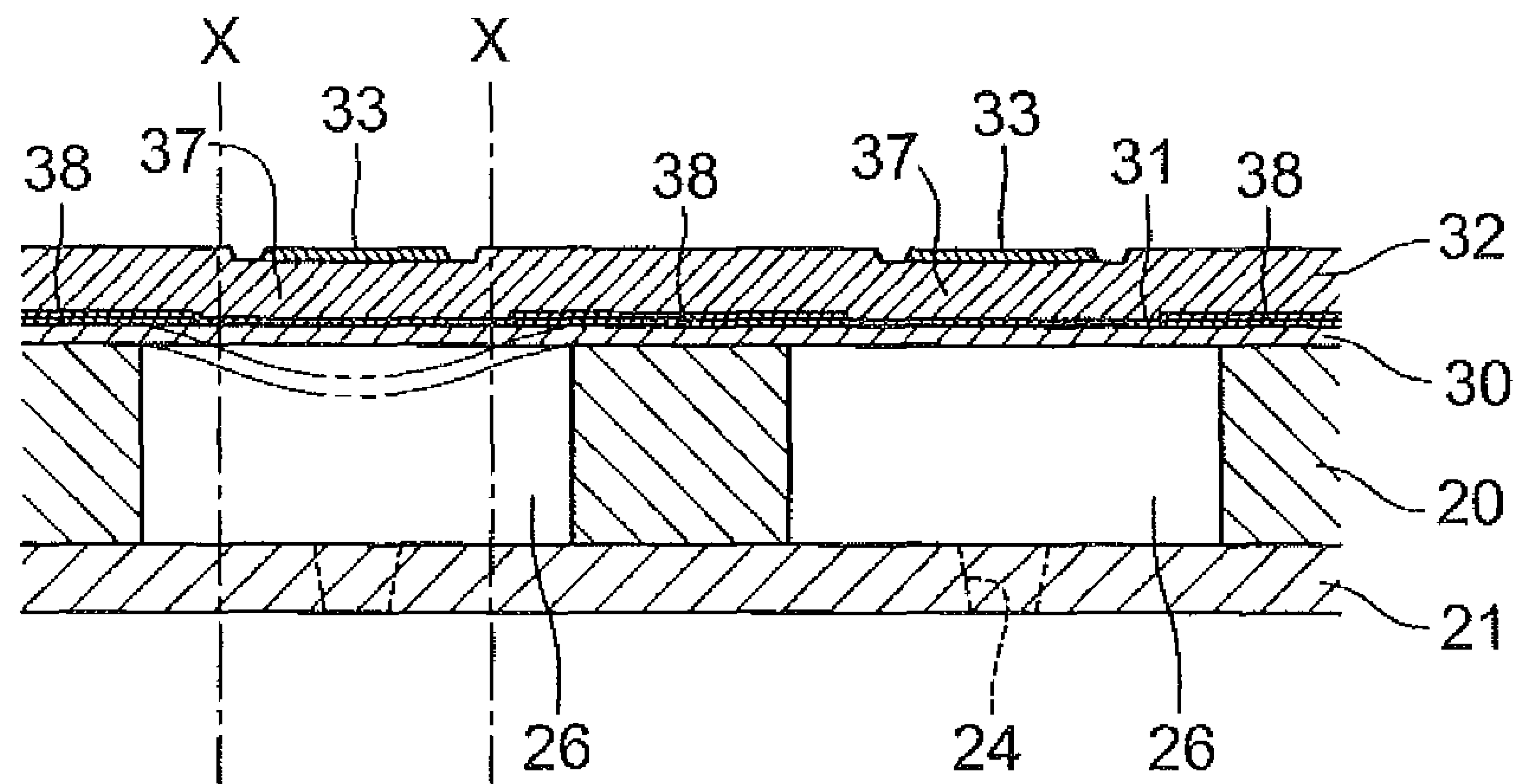


Fig.6A

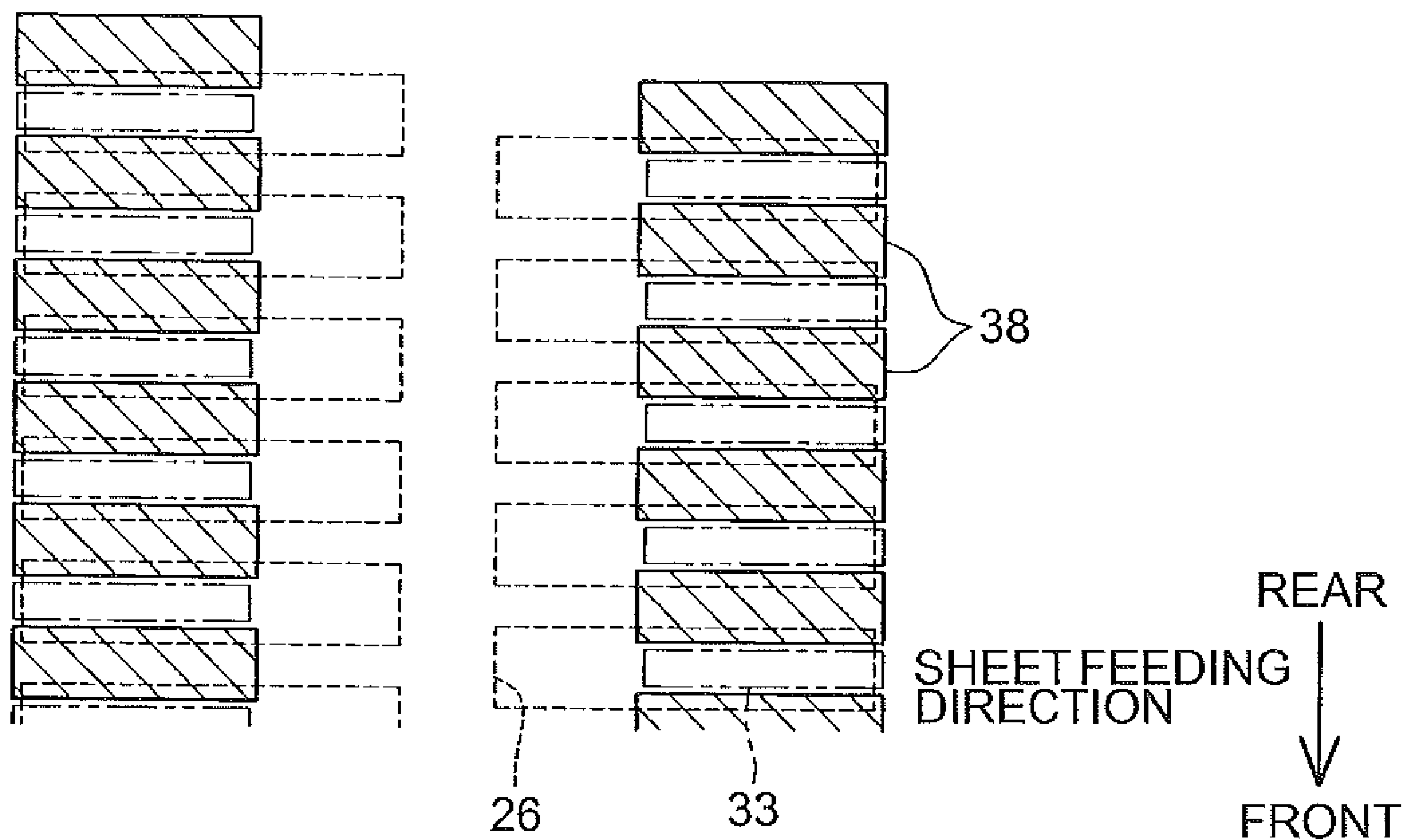


Fig.6B

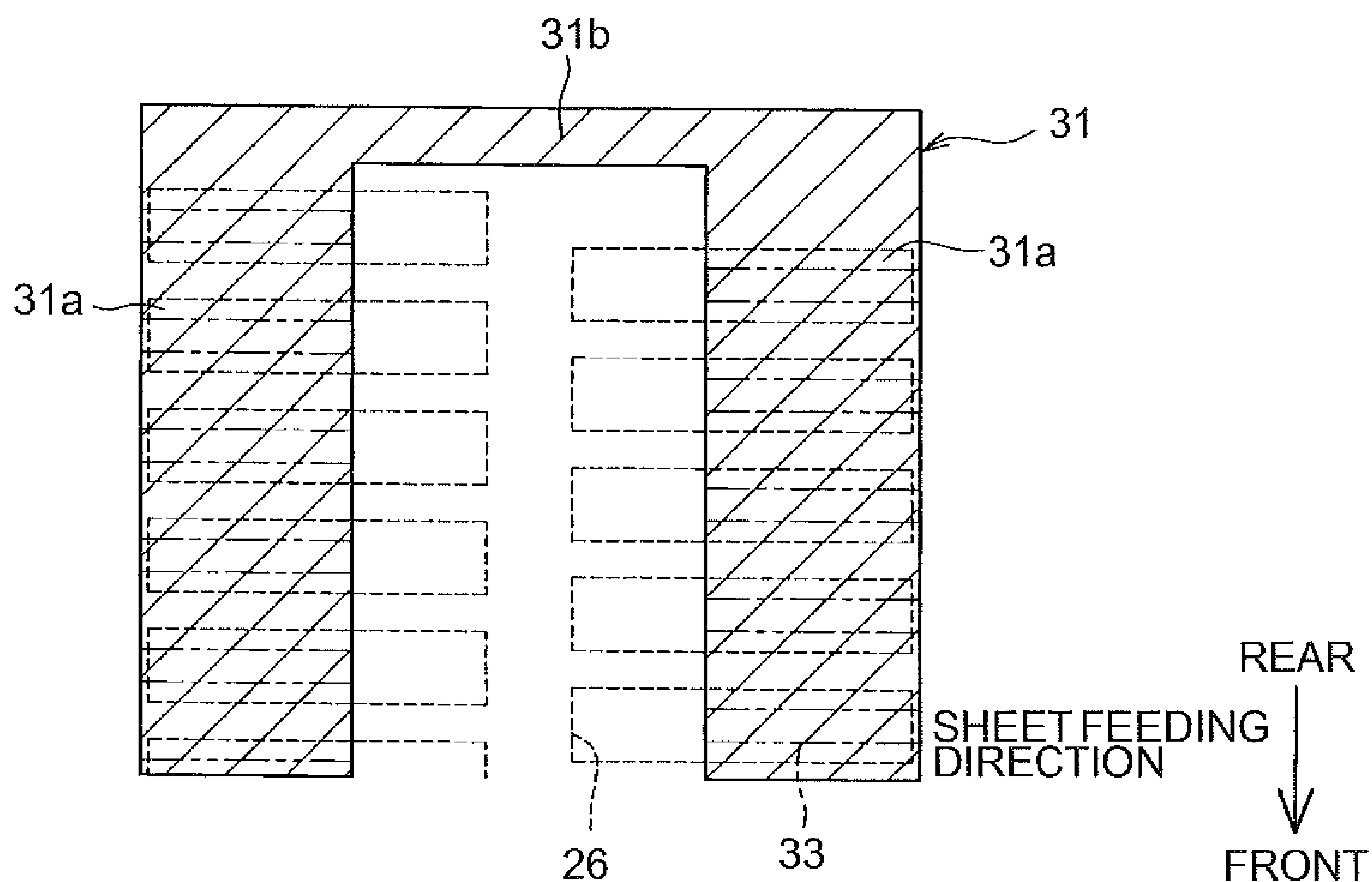


Fig.7A

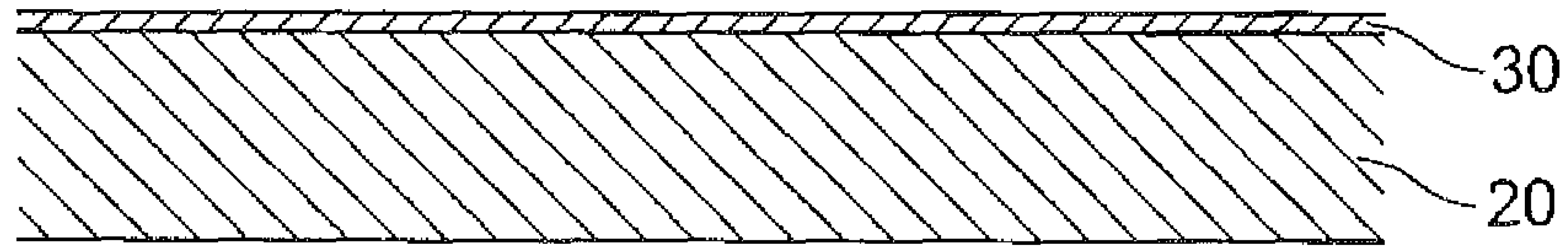


Fig.7B

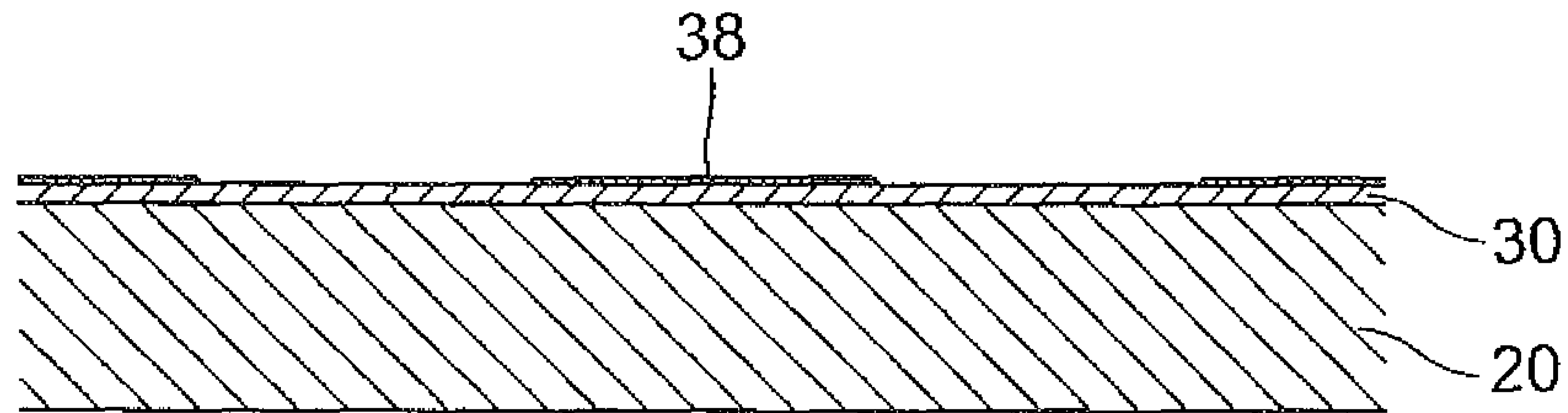


Fig.7C

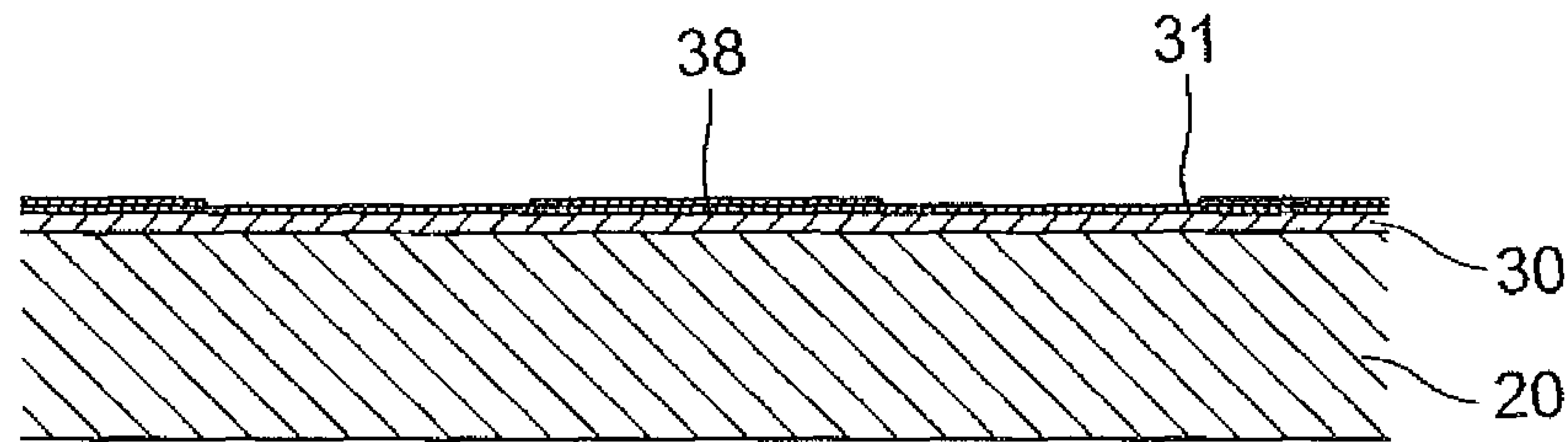


Fig.7D

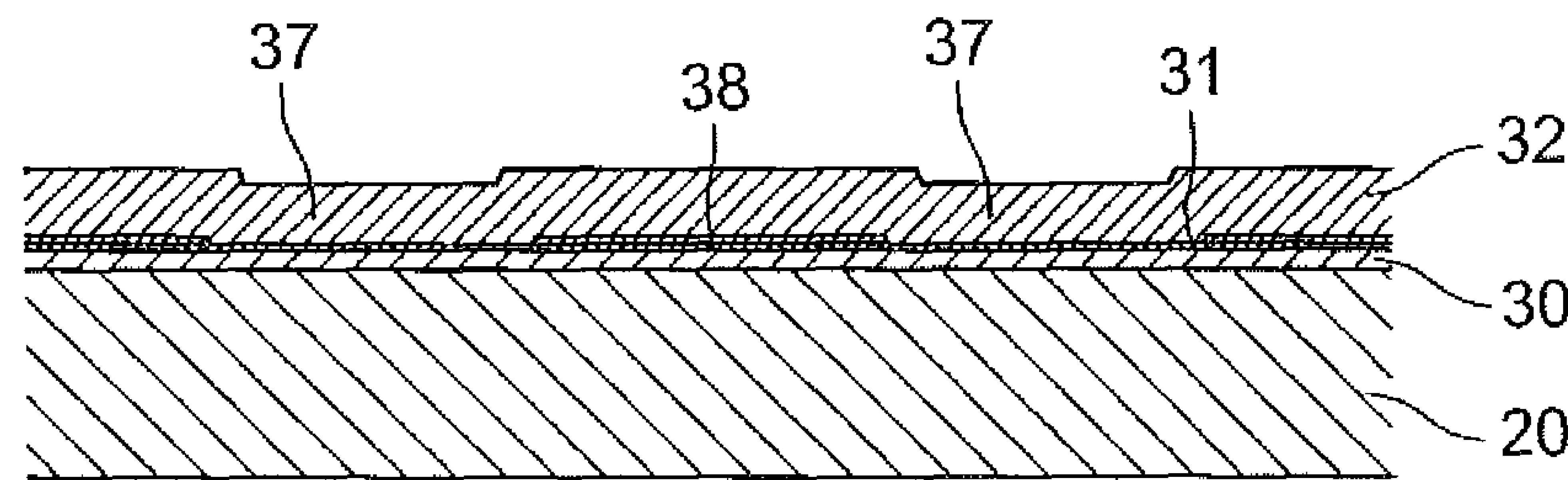


Fig.7E

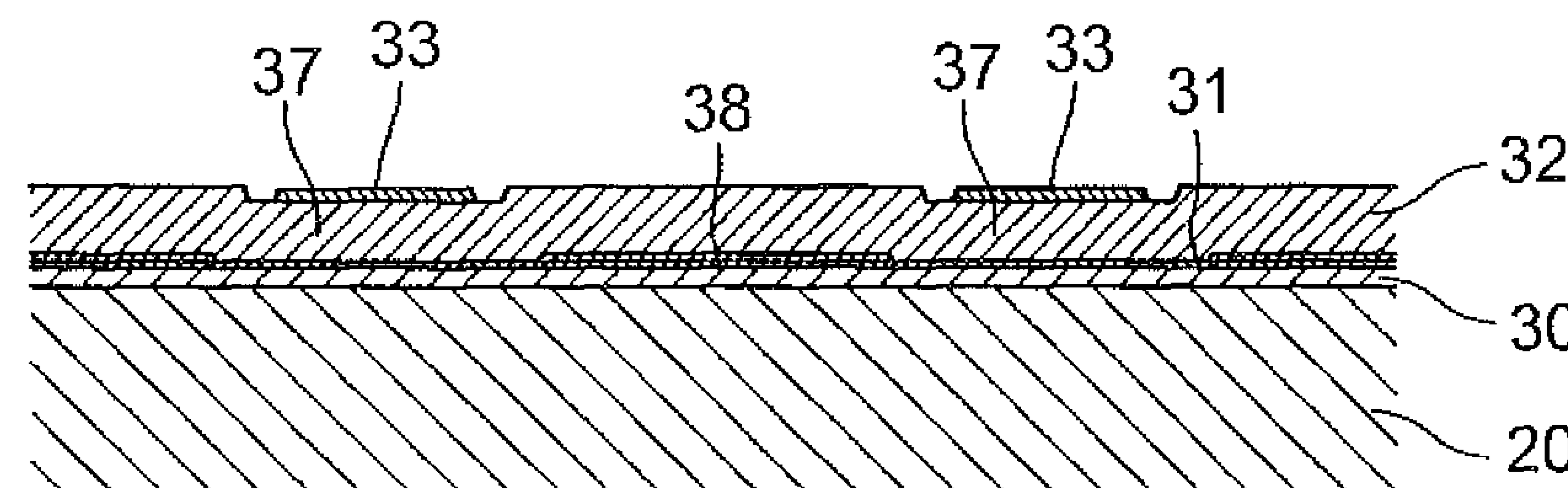


Fig.8A

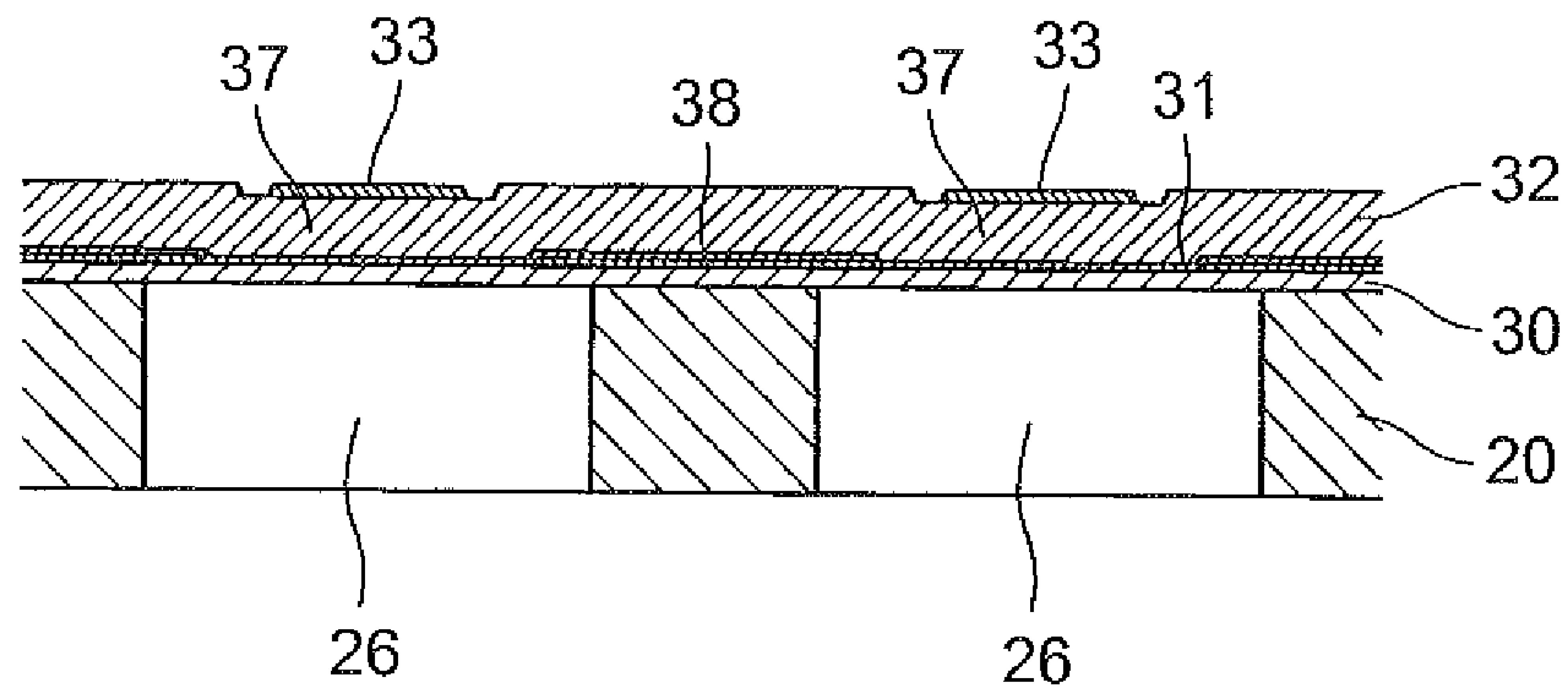


Fig.8B

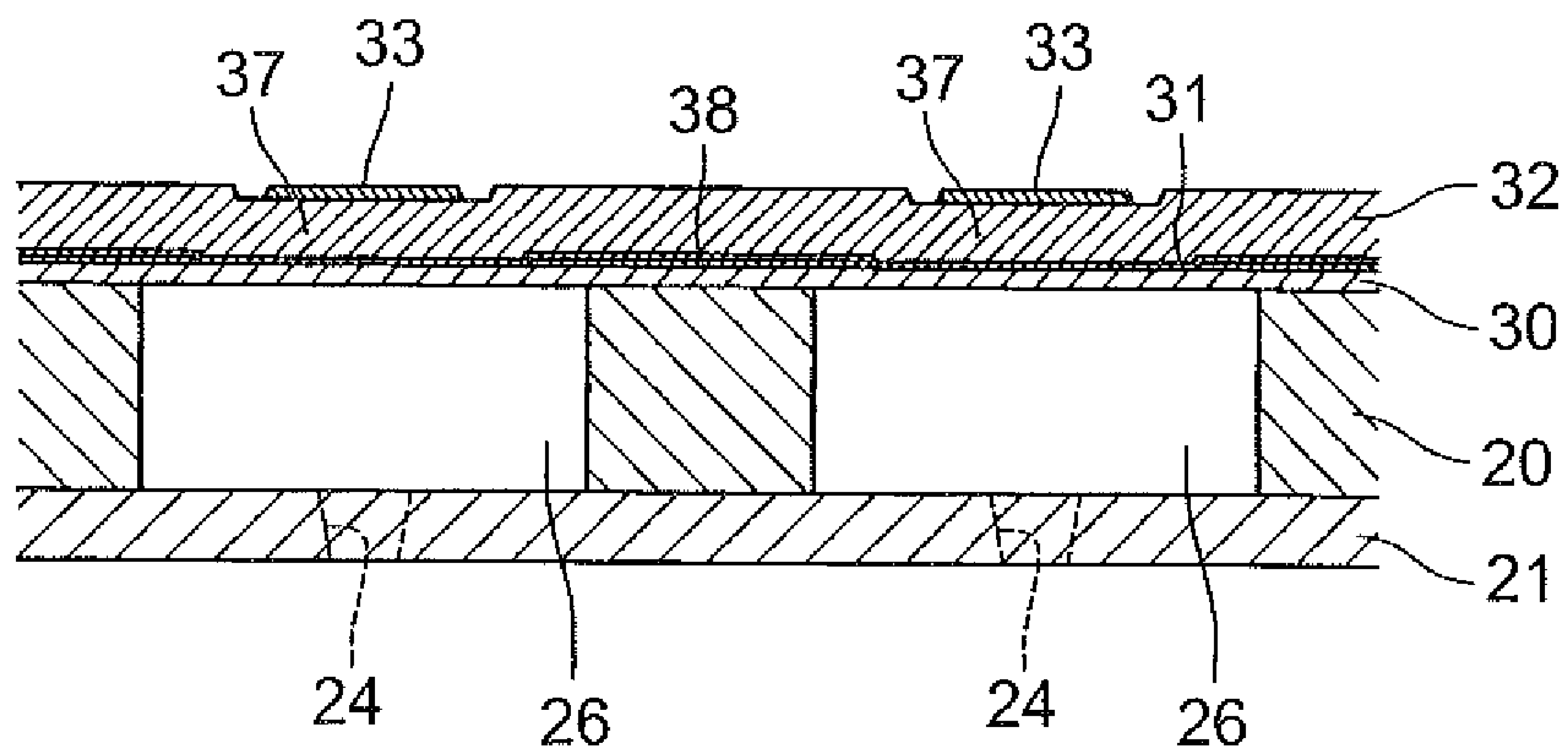
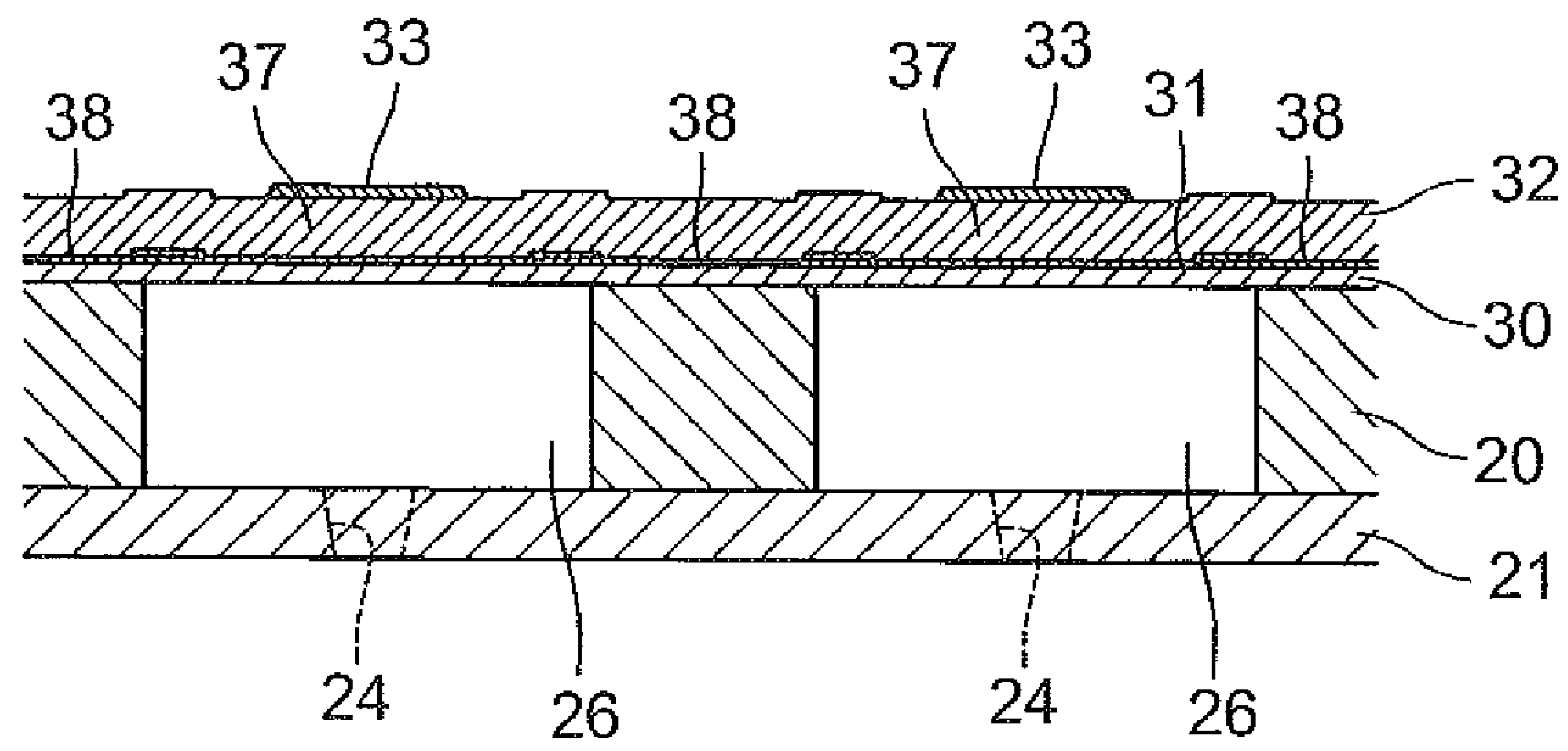


Fig.9

38 37 33 38 37 33 31 38 32 30 20 21 24 26 24 26

Fig.10



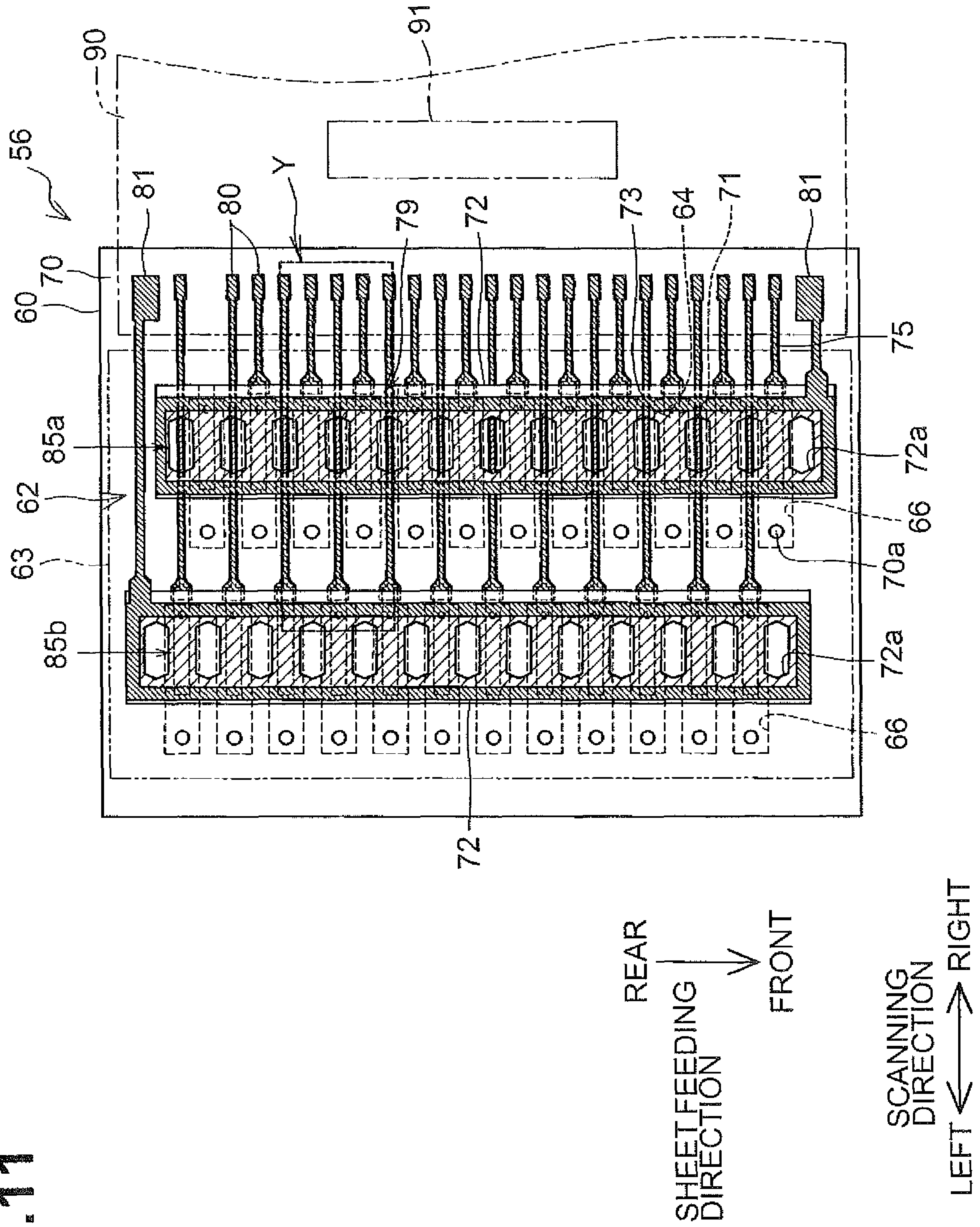


Fig.11

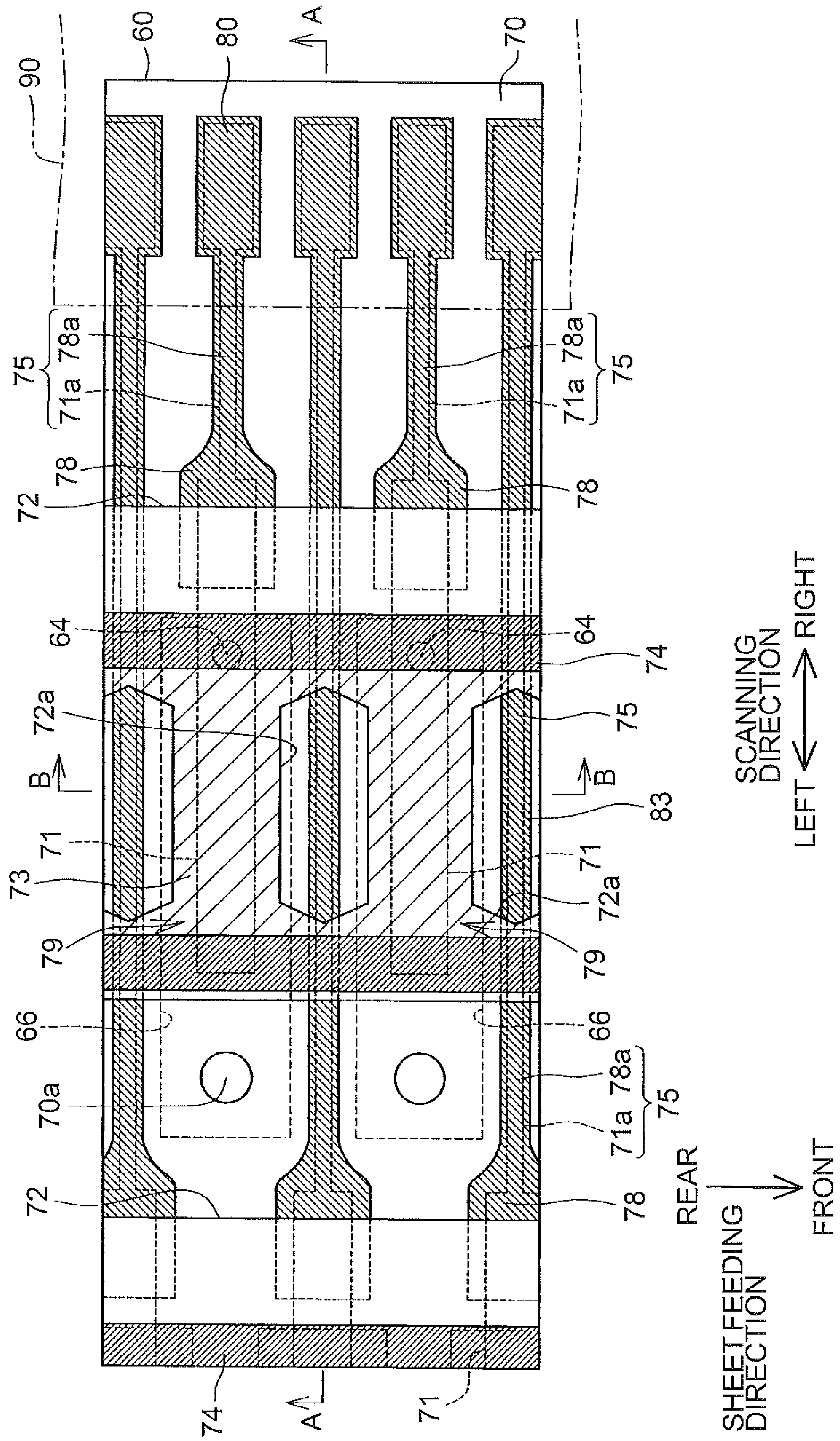


Fig.12
60
80
A
70
90
75
78a
71a
78
72
64
74
72a
B
71
73
79
83
66
70a
SCANNING DIRECTION
LEFT
RIGHT
REAR
FRONT
SHEET FEEDING DIRECTION

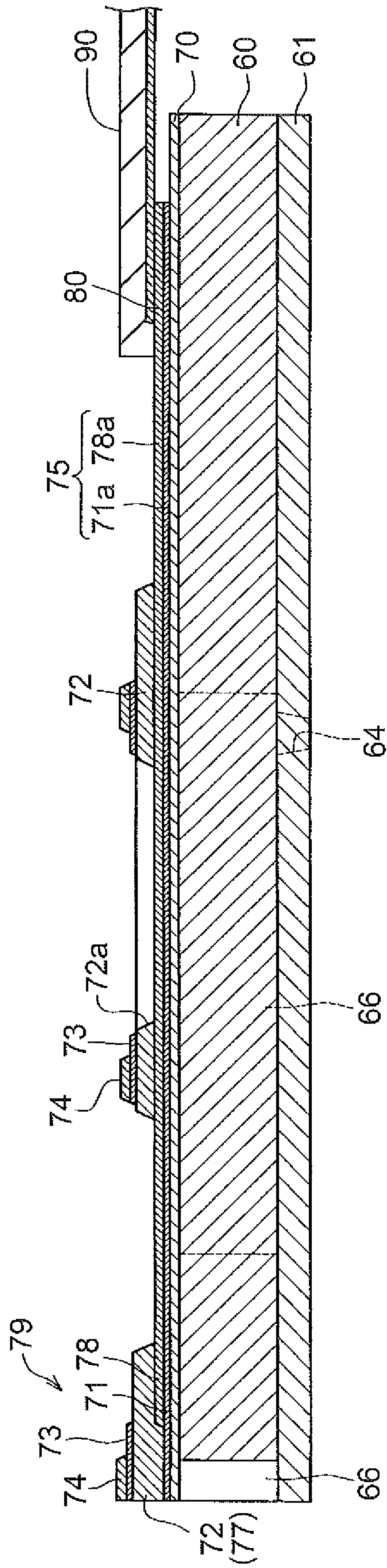


Fig.13A

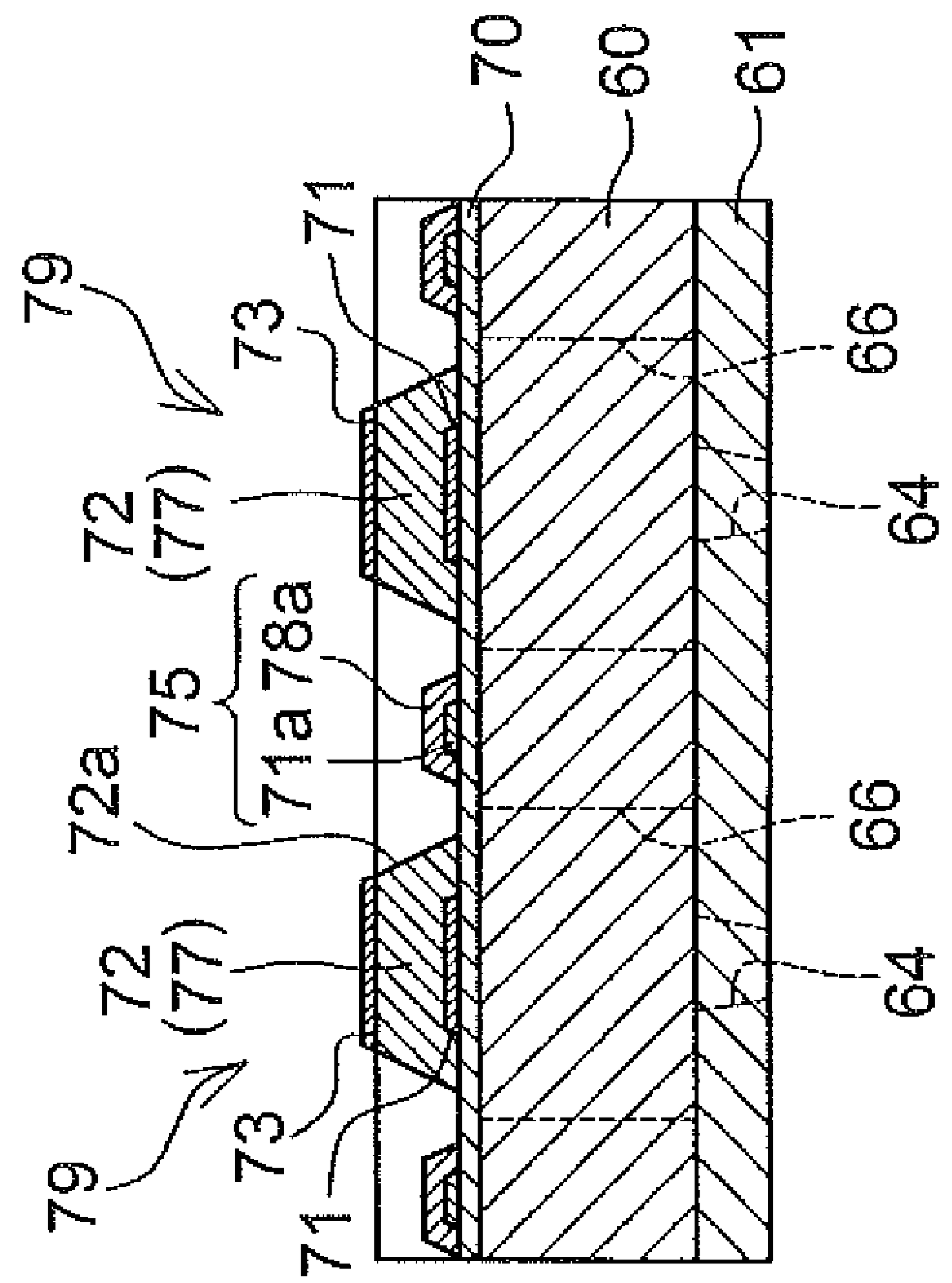


Fig.13B

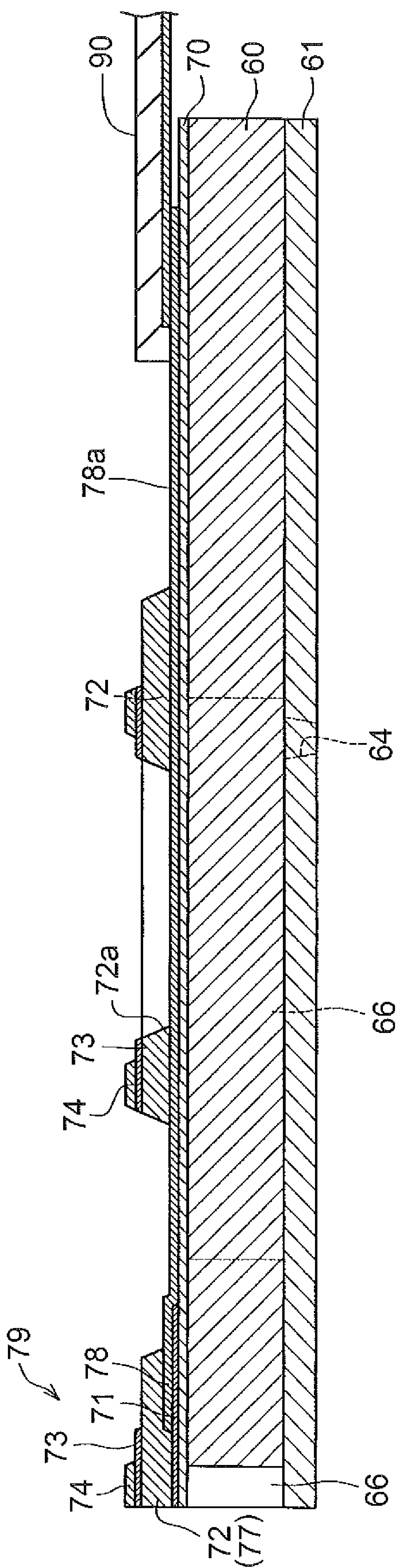


Fig.14

LIQUID EJECTION APPARATUS AND METHOD OF FORMING LIQUID EJECTION APPARATUS

Matter enclosed in heavy brackets [ ] appears in the original patent but forms no part of this reissue specification; matter printed in italics indicates the additions made by reissue; a claim printed with strikethrough indicates that the claim was canceled, disclaimed, or held invalid by a prior post-patent action or proceeding.

CROSS-REFERENCE TO RELATED APPLICATION

[This**]** *The present* application *is a reissue of U.S. Pat. No. 9,682,558, which further* claims priority from Japanese Patent Application No. 2014-264177 filed on Dec. 26, 2014, *both of* which **[**is**]** *are* incorporated herein by reference in **[**its**]** *their* entirety.

BACKGROUND

1. Technical Field

The present disclosure relates to a liquid ejection apparatus.

2. Description of the Related Art

Japanese Patent No. 4811598 discloses an inkjet head as a liquid ejection apparatus. The inkjet head includes piezoelectric elements for ejection of a liquid. The inkjet head includes a channel defining substrate, which has a plurality of pressure chambers, and piezoelectric elements disposed for the corresponding pressure chambers of the channel defining substrate. The piezoelectric elements each include a piezoelectric film, a lower electrode film disposed below the piezoelectric film, and an upper electrode film disposed above the piezoelectric film. The lower electrode film is a common electrode for the piezoelectric elements. The upper electrode film is an individual electrode and is disposed for each of the piezoelectric elements. The lower electrode film includes a conductor layer mainly composed of platinum.

SUMMARY

The thickness of the electrode is desired to be as thin as possible to reduce the cost if the electrode disposed below the piezoelectric film is made of platinum, which is expensive. In addition, the electrode having a large thickness may inhibit deformation of the piezoelectric film. However, reduction in the thickness of the electrode to overcome these problems increases the electrical resistance of the electrode, which adversely affects the behaviors (such as responsiveness) of the piezoelectric elements.

It is an object of the present disclosure to reduce the thickness of the electrode made of platinum to achieve a low cost and to reduce the substantial electrical resistance of the electrode.

According to an aspect of the disclosure, a liquid ejection apparatus includes a pressure chamber; a diaphragm covering the pressure chamber; a piezoelectric element having a piezoelectric component positioned opposing the pressure chamber; a first electrode disposed on a first side of the piezoelectric component toward the pressure chamber; a second electrode disposed on a second side of the piezoelectric component opposite the first side in an opposed region, the opposed region being a region opposed to the second electrode; and a metal film disposed between the piezoelectric component and the diaphragm, the metal film being absent from at least a portion of the opposed region. The metal film and the first electrode are in electrical contact with each other. The first electrode is made of platinum and the metal film is made of a metal material other than platinum.

According to a further aspect of the disclosure, a method of forming a liquid ejection apparatus is disclosed. The method includes forming a diaphragm layer on a surface of a substrate; forming a metal film in a first region; and forming a first electrode in the first region and in a second region, the first electrode layer being made of platinum and electrically contacting the metal film. The method also includes forming a piezoelectric layer over the first electrode layer; and forming a second electrode over the piezoelectric layer in the second region. The metal film is absent from at least a portion of the second region, and is made of a metal material other than platinum.

BRIEF DESCRIPTION OF THE DRAWINGS

FIG. **1** is a schematic plan view illustrating a printer according to an embodiment.

FIG. **2** is a top view of one of head units of an inkjet head.

FIG. **3** is a magnified view of a section indicated by X in FIG. **2**.

FIG. **4** is a cross-sectional view taken along a line IV-IV in FIG. **3**.

FIG. **5** is a cross-sectional view taken along a line V-V in FIG. **3**.

FIG. **6**A is a plan view of metal films.

FIG. **6**B is a plan view of a lower electrode on the metal films.

FIGS. **7**A to **7**E are views illustrating steps of forming a diaphragm, metal films, a lower electrode, a piezoelectric component, and upper electrodes, respectively, as steps of producing the inkjet head.

FIGS. **8**A and **8**B are views illustrating a step of etching a channel substrate and a step of bonding a nozzle plate, respectively, as steps of producing the inkjet head.

FIG. **9** is a cross-sectional view illustrating a head unit according to a first modification and corresponding to FIG. **5**.

FIG. **10** is a cross-sectional view illustrating a head unit according to a second modification and corresponding to FIG. **5**.

FIG. **11** is a top view illustrating one of head units of an inkjet head according to a seventh modification.

FIG. **12** is a magnified view of a section indicted by Y in FIG. **11**.

FIG. **13**A and FIG. **13**B are cross-sectional views taken along a line A-A and a line B-B respectively in FIG. **12**.

FIG. **14** is a cross-sectional view illustrating a head unit according to an eighth modification and corresponding to FIG. **13**A.

DESCRIPTION OF THE PREFERRED EMBODIMENTS

An embodiment of the present disclosure is described below. FIG. **1** is a schematic plan view illustrating a printer in the embodiment. An overall configuration of an inkjet printer **1** is described with reference to FIG. **1**. In this specification, front, rear, left, and right sides in FIG. **1** are defined as front, rear, left, and right sides of a printer. A side facing the viewer is defined as an upper side and a side away from the viewer is defined as a lower side. Hereinafter, terms

such as front, rear, left, right, upper, and lower sides are suitably used to describe the embodiment.

Overall Configuration of Printer

As illustrated in FIG. **1**, the inkjet printer **1** includes a platen **2**, a carriage **3**, an inkjet head **4**, a transport mechanism **5**, a controller **6**, and other components.

A recording sheet **100** as a recording medium is placed on an upper surface of the platen **2**. The carriage **3** is configured to be reciprocated in a left-right direction, which may be referred to as a scanning direction hereinafter, along two guide rails **10** and **11** in an area facing the platen **2**. An endless belt **14** connected to the carriage **3** is rotated by a carriage drive motor **15** to move the carriage **3** in the scanning direction.

The inkjet head **4** is mounted on the carriage **3** so as to be moved in the scanning direction together with the carriage **3**. The inkjet head **4** includes four head units **16** arranged in the scanning direction. The head units **16** are each connected, through a tube (not illustrated), to a cartridge holder **7** that holds ink cartridges **17** of four colors (black, yellow, cyan, and magenta). Each head unit **16** includes a plurality of nozzles **24** (see FIG. **2** to FIG. **4**) at a lower surface thereof (surface at the side facing away from the viewer in FIG. **1**). The nozzles **24** of each head unit **16** eject ink supplied from the ink cartridge **17** to the recording sheet **100** on the platen **2**.

The transport mechanism **5** includes two transport rollers **18** and **19** disposed in the front-rear direction with the platen **2** being disposed therebetween. The transport mechanism **5** transports the recording sheet **100** on the platen **2** to the front (in a transport direction) by the transport rollers **18** and **19**.

The controller **6** includes a Read Only Memory (ROM), a Random Access Memory (RAM), and an Application Specific Integrated Circuit (ASIC) including various control circuits, for example. The controller **6** directs the ASIC to execute various operations such as a printing operation on the recording medium **100** in accordance with a program in the ROM. In the printing operation, for example, the controller **6** controls the inkjet head **4**, the carriage drive motor **15**, and other components to print an image on the recording medium **100** based on a printing instruction input by an external device such as a PC. Specifically, the printing is performed by alternately repeating an ink ejection operation in which the inkjet head **4** ejects the ink while being moved in the scanning direction together with the carriage **3** and a transport operation in which the transport rollers **18** and **19** transport the recording sheet **100** a predetermined distance in the transport direction.

Detailed Description of Inkjet Head

The inkjet head **4** is described in detail. FIG. **2** is a top view of one of head units **16** of the inkjet head **4**. The inkjet head **4** includes four identical head units **16**. The configuration of one of the head units **16** is described and description of the other head units **16** is omitted. FIG. **3** is a magnified view of a section indicated by X in FIG. **2**. FIG. **4** is a cross-sectional view taken along a line IV-IV in FIG. **3**. FIG. **5** is a cross-sectional view taken along a line V-V in FIG. **3**.

As illustrated in FIG. **2** to FIG. **5**, the head unit **16** includes a channel substrate **20**, a nozzle plate **21**, a piezoelectric actuator **22**, and a reservoir defining member **23**. In FIG. **2**, the reservoir defining member **23**, which is positioned above the channel substrate **20** and the piezoelectric actuator **22**, is outlined by a two-dotted chain line to simplify the figure. In addition, a COF **50**, which is illustrated by a solid line in FIG. **4**, is indicated by a two-dotted chain line in FIG. **2** and FIG. **3**.

Channel Substrate

The channel substrate **20** is a monocrystalline silicon substrate. The channel substrate **20** includes a plurality of pressure chambers **26**. As illustrated in FIG. **2** and FIG. **3**, the pressure chambers **26** each have a rectangular shape elongated in the scanning direction in plan view. The pressure chambers **26** are arranged in the transport direction so as to form two pressure chamber rows arranged side by side in the scanning direction. The channel substrate **20** further includes a diaphragm **30** that covers the pressure chambers **26**. The diaphragm **30** is a silicon dioxide (SiO_2) film or a silicon nitride (SiNx) film that is obtained by partially oxidizing or nitriding the channel substrate **20** made of silicon. The diaphragm **30** has a plurality of communication holes **30**a to allow a channel in the reservoir defining member **23**, which is described later, and the pressure chambers **26** to be in communication with each other.

Nozzle Plate

The nozzle plate **21** is bonded to a lower surface of the channel substrate **20**. The nozzle plate **21** includes a plurality of nozzles **24** that are in communication with the pressure chambers **26** of the channel substrate **20**. As illustrated in FIG. **2**, the nozzles **24** are arranged in the transport direction so as to form two nozzle rows **25**a and **25**b arranged side by side in the scanning direction as the pressure chambers **26**. Each nozzle **24** in the nozzle row **25**a is offset from the corresponding nozzle **24** in the nozzle row **25**b in the transportation direction by a half of a pitch P (P/2) of the nozzle rows **25**a and **25**b. A material of the nozzle plate **21** is not particularly limited. The nozzle plate **21** may be made of a metal material such as stainless steel, silicon, or a synthetic resin material such as polyimide.

Piezoelectric Actuator

The piezoelectric actuator **22** is configured to apply ejection energy to the ink in the pressure chambers **26** so as to allow the ink to be ejected through the nozzles **24**. The piezoelectric actuator **22** is disposed on an upper surface of the diaphragm **30** of the channel substrate **20**. As illustrated in FIG. **2** to FIG. **4**, the piezoelectric actuator **22** on the upper surface of the diaphragm **30** includes a plurality of piezoelectric elements **39** disposed so as to correspond to the pressure chambers **26**, which are arranged in two rows, and a plurality of traces **35** corresponding to the piezoelectric elements **39**, for example.

Hereinafter, the piezoelectric elements **39** of the piezoelectric actuator **22** and other associated components are sequentially described. Each piezoelectric element **39** includes a piezoelectric portion **37**, a lower electrode **31** disposed on a lower surface (surface adjacent to the diaphragm **30**) of the piezoelectric portion **37**, and an upper electrode **33** disposed on an upper surface (surface remote from the diaphragm **30**) of the piezoelectric portion **37**.

The lower electrode **31** is disposed on an upper surface of the diaphragm **30** so as to be positioned over the pressure chambers **26** corresponding to the piezoelectric elements **39**. Specifically, as illustrated in FIG. **2** and FIG. **6**, the lower electrode **31** includes two first electrode sections **31**a extending in the transport direction along with the two pressure chamber rows and two second electrodes **31**b each connecting corresponding ends in the transport direction of the first electrode sections **31**a to form a rectangular frame shape in plan view. The lower electrode **31** is a common electrode for the piezoelectric elements **39**. In other words, electrode sections of the lower electrode **31** facing the pressure chambers **26** are electrically connected and integrated. The lower electrode **31** is made of platinum (Pt).

In this embodiment, as illustrated in FIG. **5**, a metal film **38** that is made of a material other than platinum is stacked on the lower electrode **31**. The metal film **38** is positioned below the lower electrode **31**, i.e., between the lower electrode **31** and the diaphragm **30**. The metal film **38** is described in detail later.

As illustrated in FIG. **2**, two piezoelectric components **32** each extending in the transport direction are disposed above the lower electrode **31** so as to correspond to the two pressure chamber rows. As illustrated in FIG. **4**, the piezoelectric components **32** each have left and right sides that are inclined inwardly with respect to a plane perpendicular to the diaphragm **30**. The piezoelectric components **32** each have a trapezoidal cross-sectional shape having an upper surface wider than a lower surface.

The piezoelectric components **32** each have a rectangular shape elongated in the transport direction in plan view. Each piezoelectric component **32** has drive portions, which apply pressures to the pressure chambers **26**, at positions facing the pressure chambers **26**. The drive portions are referred to as piezoelectric portions **37**. In other words, the piezoelectric portions **37** arranged in the transport direction are connected to constitute one piezoelectric component **32**. Each piezoelectric component **32** is stacked on the lower electrode **31** so as to extend across the pressure chambers **26** in one of the pressure chamber rows. The lower electrode **31** is disposed on the lower surface (adjacent to the diaphragm **30**) of the piezoelectric component **32**. Each piezoelectric component **32** is made of a piezoelectric material including lead zirconate titanate (PZT) as a main component, for example. The lead zirconate titanate is a mixed crystal including lead titanate and lead zirconate. Alternatively, the piezoelectric component **32** may be made of a lead-free piezoelectric material.

The upper electrodes **33** are disposed on the upper surfaces of the piezoelectric components **32** in the regions opposed to the pressure chambers **26**. The upper electrodes **33** are individual electrodes and are disposed on the corresponding piezoelectric elements **39**. The shape of each upper electrode **33** is not particularly limited, but may be a rectangular shape that is smaller than the pressure chamber **26** in plan view as illustrated in FIG. **3**. The upper electrodes **33** are made of iridium (Ir), for example.

The piezoelectric portions **37** sandwiched between the lower electrode **31** and the upper electrodes **33** are polarized in the thickness direction toward a lower side, i.e., from the upper electrodes **33** to the lower electrode **31**.

As illustrated in FIG. **2** to FIG. **4**, the traces **35** are each connected to the upper electrodes **33** of the piezoelectric elements **39** at one end. Each trace **35** extends from the upper electrode **33** along the inclined surface of the piezoelectric component **32** to an upper surface of the diaphragm **30**. The material of the trace **35** is not particularly limited, and may be gold (Au) or aluminum (Al).

The trace **35** extends from the corresponding piezoelectric element **39** in the scanning direction parallel to the surface of the diaphragm **30**. Specifically, as illustrated in FIG. **2**, the traces **35** extend from the piezoelectric elements **39** on the left toward the left and the traces **35** extend from the piezoelectric elements **39** on the right toward the right. Each trace **35** includes a driving contact **40** at the other end remote from the piezoelectric element **39**. The driving contacts **40** of the traces **35** are arranged in the transport direction on left and right end sections of the channel substrate **20** (diaphragm **30**).

Four traces **36** including two left and two right traces **36** are connected to the lower electrode **31**. The two left traces **36** and the two right traces **36** extend from the lower electrode **31** to the left and to the right, respectively. One end of each trace **36** includes a ground contact **41**. The ground contacts **41** and the driving contacts **40** form one line on each of the left and right end sections of the channel substrate **20** (diaphragm **30**).

As illustrated in FIG. **2** to FIG. **4**, two COFs **50** are connected to the respective left and right end sections of the diaphragm **30** of the channel substrate **20**. Traces **55** of the COFs **50** are electrically connected to the driving contacts **40**. Although not illustrated, the COFs **50** are also connected to the controller **6** (see FIG. **1**).

A driver IC **51** is mounted on each COF **50**. The driver IC **51** generates and outputs driving signals for driving the piezoelectric actuator **22** based on a control signal from the controller **6**. The driving signals output by the driver IC **51** are received by the driving contacts **40** through the traces **55** of the COF **50** and supplied to the upper electrodes **33** through the traces **35** of the piezoelectric actuator **22**. The upper electrodes **33** that have received the driving signals change in potential from the ground potential to a predetermined potential. The COF **50** further has ground traces (not illustrated) that are electrically connected to the ground contact **41** of the piezoelectric actuator **22**. This configuration enables the potential of the lower electrode **31** connected to the ground contact **41** to be maintained at the ground potential.

The piezoelectric actuator **22** that has received the driving signal from the driver IC **51** operates as follows. Before the reception of the driving signal, the potential of each of the upper electrodes **33** is a ground potential, which is the same potential as the lower electrode **31**. When the upper electrode **33** in such a state receives the driving signal, the potential thereof is changed to the driving potential. A potential difference between the upper electrode **33** and the lower electrode **31** generates parallel electric fields extending in the thickness direction of the piezoelectric portion **37**. Since the direction of polarization of the piezoelectric portion **37** and the direction of the electric field are equal, the piezoelectric portion **37** elongates in the thickness direction, which is the direction of the polarization, and contracts in the planar direction. Due to such contraction deformation of the piezoelectric portion **37**, the diaphragm **30** protrudes toward the pressure chamber **26**. With this configuration, the volume of the pressure chamber **26** is reduced and a pressure wave is generated in the pressure chamber **26**, which allows ink droplets to be ejected through the nozzle **24** in communication with the pressure chamber **26**.

In this embodiment, the lower electrode **31** as the common electrode is made of platinum, which is expensive. The thickness of the lower electrode **31** is desired to be as small as possible to reduce cost. In addition, the deformation of the piezoelectric portion **37** is more likely to be inhibited as the thickness of the lower electrode **31** increases, and thus the lower electrode **31** is desired to have a small thickness. However, the reduction in the thickness of the lower electrode **31** increases the electrical resistance of the common electrode, which adversely affects the behavior of each piezoelectric element **39**. The amount of the voltage drop between the ground contact **41** and the lower electrode **31** differs depending on the distance between the ground contact **41** and the piezoelectric element **39**, for example. In the piezoelectric element **39** remote from the ground contact **41**, the potential of the lower electrode **31** is likely to vary and become unstable, which adversely affects ejection properties such as responsiveness.

To solve such a problem, as illustrated in FIG. **5**, the metal film **38** made of a material other than platinum is disposed between the piezoelectric component **32** and the diaphragm **30** of the channel substrate **20** in this embodiment. The lower electrode **31** is stacked on the metal film **38** so as to be in direct contact with the metal film **38**. FIG. **6**A is a plan view of the metal film **38** and FIG. **6**B is a plan view of the lower electrode **31** on the metal film **38**. In FIGS. **6**A and **6**B, the pressure chambers **26** that are positioned below (facing away from the viewer in FIG. **6**) the metal film **38** and the lower electrode **31** are indicated by a broken line and the upper electrodes **33** positioned above (facing the viewer in FIG. **6**) the metal film **38** and the lower electrode **31** are indicated by a two dotted chain line.

As illustrated in FIG. **6**B, the lower electrode **31** includes the two first electrode sections **31**a positioned so as to correspond to the two pressure chamber rows and the second electrode section **31**b connecting the two first electrode sections **31**a. The first electrode sections **31**a each extend over the pressure chambers **26** in the corresponding pressure chamber row. The metal films **38** are disposed in non-opposed regions of the first electrode sections **31**a of the lower electrode **33**, which are defined as being outside the regions opposed to the upper electrodes **33**, and are in direct contact with the lower electrode **31**. Specifically, as illustrated in FIG. **6**A, the metal films **38** are disposed between the upper electrodes **33** arranged in the transport direction, while the lower electrode **31** is disposed over the entire area of each of the metal films **38** so as to be in contact with the metal films **38**.

The configuration in which the metal films **38** are in direct contact with the lower electrode **31** enables the lower electrode **31** made of platinum to have a reduced thickness and to have a reduced substantial electrical resistance. The thickness of the lower electrode **31** may be reduced to 0.1 μm or smaller (preferably, 0.05 μm or less), for example. In addition, since the metal films **38** does not face the upper electrodes **33** (piezoelectric portions **37**), the deformation of the piezoelectric portions **37** are unlikely to be inhibited by the metal films **38** stacked on the lower electrode **31**. In the embodiment, since the entire area of the metal films **38** is in contact with the lower electrode **31**, the substantial electrical resistance of the lower electrode **31** is largely reduced.

As illustrated in FIG. **5**, the metal film **38** is preferably thicker than the lower electrode **31**. The substantial electrical resistance of the lower electrode **31** is largely reduced due to the metal film **38** being thicker than the lower electrode **31**. Since the metal film **38** is made of the material other than platinum, the increase in the thickness of the metal film **38** does not increase the cost compared with the increase in the thickness of the lower electrode **31**.

As illustrated in FIG. **5**, the metal film **38** is preferably positioned outside a region of the lower electrode **31** (defined between dotted chain lines X) in which the diaphragm has the maximum curvature of deformation. In this configuration, the metal film **38** is positioned outside the region in which the diaphragm **30** has the maximum curvature, and thus the metal film **38** is unlikely to inhibit the deflection of the diaphragm **30** due to the deformation of the piezoelectric portion **37**.

In the production of the piezoelectric actuator **22**, various thermal processes such as annealing of a piezoelectric material film are performed as described above. One reason why the lower electrode **31** is made of platinum is that the metal atoms constituting the lower electrode **31** are unlikely to be dispersed into the piezoelectric portion **37** during a thermal process such as annealing of the piezoelectric portion **37**. This is one of the reasons why the lower electrode **31** is made of platinum. However, if the metal film **38** made of the material other than platinum is stacked on the lower electrode **31** made of platinum and the piezoelectric portion **37** is disposed on the metal film **38**, the metal constituting the metal film **38** is likely to be dispersed into the piezoelectric portion **37**. If the metal of the metal film **38** is dispersed into the piezoelectric portion **37**, the piezoelectric portion **37** has different phases, which may cause defects such as electrical breakdown. To prevent such defects, the metal film **38** in the embodiment is disposed adjacent to the channel substrate **20**, i.e., on the opposite side of the lower electrode **31** from the piezoelectric portion **37**. This configuration reduces the dispersion of the metal of the metal film **38** into the piezoelectric portion **37**.

The metal film **38** may be made of any material other than platinum. The metal film **38** is preferably made of a metal material such as copper (Cu) and aluminum (Al) which has a low electric resistivity in view of reduction in the electrical resistance of the lower electrode **31**. The metal film **38** is heated together with the piezoelectric portion **37** during the thermal process such as annealing of the piezoelectric portion **37**. In view of this, the metal film **38** is preferably made of a metal material such as zirconium, tantalum, and tungsten, which has a high melting point.

Reservoir Defining Member

As illustrated in FIG. **4**, the reservoir defining member **23** is disposed on an opposite side (upper side) of the piezoelectric actuator **22** from the channel substrate **20** and is bonded to the upper surface of the piezoelectric actuator **22**. The reservoir defining member **23** is made of silicon as the channel substrate **20**, for example, but may be made of any material other than the silicon, such as a metal material and a synthetic resin material.

As illustrated in FIG. **4**, an upper half portion of the reservoir defining member **23** includes a reservoir **52** extending in the transport direction. The reservoir **52** is connected through tubes, which are not illustrated, to the cartridge holder **7** (see FIG. **1**), in which the ink cartridges **17** are mounted.

A lower half portion of the reservoir defining member **23** includes a plurality of ink supply channels **53** extending downward from the reservoirs **52**. Each ink supply channel **53** is in communication with the communication hole **30**a in the diaphragm **30**. This configuration allows the ink to be supplied from the reservoir **52** to the pressure chambers **26** in the channel substrate **20** through the ink supply channels **53** and the communication holes **30**a. The lower half portion of the reservoir defining member **23** further includes a protective cover portion **54** covering the piezoelectric elements **39** of the piezoelectric actuator **22**. The protective cover portion **54** does not include a wall at an opposite side (right side in FIG. **4**) from the ink supply channel **53**, and thus a space in which the piezoelectric elements **39** are disposed opens laterally.

Next, steps of producing the inkjet head **4**, particularly steps of producing the piezoelectric actuator **22** are described with reference to FIGS. **7**A to **7**E and FIGS. **8**A and **8**B. FIGS. **7**A to **7**E and FIGS. **8**A and **8**B are views each illustrating a step of producing the inkjet head **4**.

FIGS. **7**A, **7**B, **7**C, **7**D, and **7**E are views illustrating steps of forming the diaphragm **30**, the metal film **38**, the lower electrode **31**, the piezoelectric component **32**, and the upper electrode **33**, respectively.

In the embodiment, a film formation process such as sputtering and a patterning process such as etching are repeatedly performed to sequentially form various films on

the diaphragm **30** of the channel substrate **20**. As a result, the piezoelectric actuator **22** including the piezoelectric elements **39** is produced. As illustrated in FIG. **7**A, the surface of the channel substrate **20** is thermally oxidized, for example, to form the diaphragm **30** formed of silicon dioxide, for example. Then, the diaphragm **30** is etched to form the communication holes **30**a.

Then, as illustrated in FIG. **7**B, the metal films **38** are formed on the diaphragm **30** by using a material other than platinum, such as copper, aluminum, zirconium, tantalum, and tungsten. Specifically, the metal film **38** is formed over the entire upper surface of the diaphragm **30** by sputtering, for example, and then portions of the metal film **38** that is to face the upper electrodes **33** are eliminated by etching. Then, after the metal film formation, as illustrated in FIG. **7**C, the lower electrode **31** made of platinum is formed over the metal films **38**. Unlike the metal films **38**, the lower electrode **31** made of platinum extends over the regions that are to face the upper electrodes **33**.

As illustrated in FIG. **7**D, a piezoelectric material film is formed on the lower electrode **31** by the sol-gel process or sputtering, and the piezoelectric material film is patterned by dry etching to form the piezoelectric component **32** (piezoelectric portions **37**). A thermal treatment for annealing may be suitably performed to form the piezoelectric component **32**. Then, as illustrated in FIG. **7**E, the upper electrodes **33** made of iridium, for example, are formed on the upper surface of the piezoelectric component **32**. The piezoelectric actuator **22** having the piezoelectric elements **39** is produced by the above-described steps.

FIG. **8**A and FIG. **8**B are views illustrating steps of etching the channel substrate **20** and bonding the nozzle plate **21**, respectively. As illustrated in FIG. **8**A, a lower side of the channel substrate **20** which is an opposite side from the piezoelectric actuator **22** is etched so as to have the pressure chambers **26**. As illustrated in FIG. **8**B, the nozzle plate **21** is bonded to the lower surface of the channel substrate **20** by an adhesive. Then, the reservoir defining member **23** (see FIG. **4**) is bonded to the piezoelectric actuator **22** by an adhesive.

In the above-described embodiment, the inkjet head **4** corresponds to the "liquid ejection apparatus" of the present disclosure. The lower electrode **31** and the upper electrode **33** correspond to the "first electrode" and the "second electrode" in the present disclosure respectively.

Next, various modifications of the above-described embodiment are described. Components in the modifications identical to those in the embodiment are assigned reference numerals the same as those in the embodiment and are not described in detail.

First Modification

In the embodiment illustrated in FIG. **5**, the metal films **38** are disposed below the lower electrode **31** (adjacent to the diaphragm **30**), but may be disposed above the lower electrode **31** (remote from the diaphragm **30**) as illustrated in FIG. **9**.

Second Modification

In the embodiment, the entire area of each metal film **38** is in direct contact with the lower electrode **31**. However, as illustrated in FIG. **10**, a part of the metal film **38** may be in contact with the lower electrode **31**. This configuration, in which the part of the metal film **38** is in contact with the lower electrode **31** made of platinum, reduces the amount of platinum, which is expensive, and reduces the substantial electrical resistance of the lower electrode **31**.

Third Modification

In the embodiment, the metal film **38** stacked on the lower electrode **31** has a thickness greater than that of the lower electrode **31**. However, the metal film **38** may have a thickness equal to or smaller than that of the lower electrode **31**.

Fourth Modification

In the embodiment, the piezoelectric portions **37** of the piezoelectric elements **39** arranged in a nozzle arrangement direction in which the nozzles are arranged (transport direction) are connected to form one piezoelectric component **32** as illustrated in FIG. **2** and FIG. **3**. However, the piezoelectric portions **37** of the piezoelectric elements **39** may separate from each other.

Fifth Modification

In the embodiment, the metal films **38** are separately disposed in non-opposed regions of the lower electrode **31**, which are defined as being outside regions opposed to the upper electrodes **33** and positioned between the upper electrodes **33**, as illustrated in FIG. **6**A. However, the metal films **38** in the non-opposed regions may be connected to each other.

Sixth Modification

In the embodiment, as illustrated in FIG. **6**A, the metal films **38** on the lower electrode **31** are disposed in the non-opposed regions, which are defined as being outside the region opposed to the upper electrode **33** and positioned between the upper electrodes **33**. However, the metal film **38** is not necessarily disposed in every one of the non-opposed regions. The metal film **38** may be disposed in some of the non-opposed regions.

Seventh Modification

In the piezoelectric actuator **22** in the embodiment, the lower electrode **31** is the common electrode for the piezoelectric elements **39** and each upper electrode **33** is the individual electrode for each of the piezoelectric elements **39**. However, the technique in the present disclosure may be applied to an opposite electrode configuration in which the piezoelectric element has the lower electrode as the individual electrode and the upper electrode as the common electrode.

The following is an example of the configuration including lower electrodes as the individual electrodes and an upper electrode as the common electrode. FIG. **11** is a plan view illustrating a head unit **56** of an inkjet head in this modification. FIG. **12** is a magnified view of a section indicated by Y in FIG. **11**. FIG. **13**A is a cross-sectional view taken along a line A-A in FIG. **12**. FIG. **13**B is a cross-sectional view taken along a line B-B in FIG. **12**.

The head unit **56** includes a channel substrate **60**, a nozzle plate **61**, a piezoelectric actuator **62**, and a reservoir defining member **63**. The configurations of the channel substrate **60**, the nozzle plate **61**, and the reservoir defining member **63** are substantially identical to those disclosed in the embodiment and are not described. Hereinafter, the configuration of the piezoelectric actuator **62** is mainly described.

As illustrated in FIG. **11** and FIG. **12**, a plurality of piezoelectric elements **79** are arranged in the transport direction so as to correspond to the pressure chambers **66** (nozzles **64**) on a diaphragm **70** of the channel substrate **60**. The piezoelectric elements **79** constitute a first and second piezoelectric element rows **85**a and **85**b are arranged in the scanning direction. A plurality of trace layers **71**a connected to the corresponding lower electrodes **71** of the piezoelectric elements **79** is disposed on the diaphragm **70**. The lower electrodes **71** and the trace layers **71**a are made of platinum. In this modification, every one of the trace layers **71**a, which

corresponds to the piezoelectric elements **79** arranged in two rows, extends to one side (right side) in the scanning direction. Driving contacts **80** for the trace layers **71**a and two ground contacts **81** are disposed on a right end section of an upper surface of the channel substrate **60**. A COF **90** on which a driver IC **91** is mounted is connected to the driving contacts **80** and the two grounding contacts **81**.

The trace layers **71**a corresponding to the piezoelectric elements **79** in the second piezoelectric element row **85**b on the left extend between the piezoelectric elements **79** (lower electrodes **71**) in the first piezoelectric element row **85**a to the right. Portions between adjacent two of the piezoelectric elements **79** (piezoelectric portions **77**) of the piezoelectric component **72** extending in the transport direction over the pressure chambers **66** are eliminated by dry etching to form openings **72**a. The openings **72**a between adjacent two of the piezoelectric elements **79** of the piezoelectric component **72** accelerate the deformation of the piezoelectric portions **77** of the piezoelectric elements **79**.

Each lower electrode **71** includes a right end portion including the trace layer **71**a. The right end portion does not face the upper electrode **73**. The metal film **78** made of a material other than platinum is disposed in the non-opposed regions of the lower electrodes **71**. In FIG. **11** to FIG. **13**B, the metal film **78** is disposed above the lower electrode **71**, but may be disposed below the lower electrode **71**. The metal film **78** may be made of any material other than platinum, which is a material of the lower electrode **71**. This configuration enables the lower electrode **71** made of platinum to have a smaller thickness, which reduces the cost, and also enables the lower electrode **71** to have a lower substantial electrical resistance, since the metal film **78** made of a material other than platinum is stacked on the lower electrode **71** made of platinum. In this configuration, the metal film **78** is preferably thicker than the lower electrode **71** to reduce the electrical resistance of the lower electrode **71**.

In this configuration, each metal film **78** includes trace layers **78**a disposed over the trace layers **71**a connected to the lower electrodes **71** in addition to the portions disposed over the lower electrodes **71**. Each trace layer **78**a extends to the driving contact **80** along the trace layer **71**a made of platinum. The trace layer **71**a made of platinum and the trace layer **78**a of the metal film **78** constitutes a trace **75** for each piezoelectric element **79**. This configuration reduces the electrical resistance of the traces **75** for the piezoelectric elements **79**.

As illustrated in FIG. **12** and FIG. **13**B, the trace layers **71**a and **78**a corresponding to the second piezoelectric row **85**b on the left are exposed through the openings **72**a of the piezoelectric component **72**, which are formed by etching, in the first piezoelectric element row **85**a on the right. If the trace **75** is partly scraped away when the piezoelectric component **72** is etched, the trace **75** is made thinner. However, in this modification, the trace **75** includes the trace layer **71**a made of platinum and the trace layer **78**a made of the metal film **78** stacked on the trace layer **71**a. Thus, the trace breakage is unlikely to occur even if the trace **75** is scraped to a certain degree during the formation of the opening **72**a by etching (particularly dry etching) the piezoelectric component **72**. This improves reliability of electric connection of the trace **75**.

Eighth Modification

In the configuration illustrated in FIG. **13**A, the trace layer **71**a made of platinum, which is the same material as the lower electrode **71**, is disposed below the trace layer **78**a of the metal film **78**. However, as illustrated in FIG. **14**, the trace layer **71**a made of platinum is an optional component and the metal film **78** may be disposed only on the lower electrode **71**.

In the above-described embodiment and the modifications, the technique in the present disclosure is applied to the piezoelectric actuator of the inkjet head, which ejects ink to the recording medium to print an image, for example. However, the technique in the present disclosure may be applied to any liquid ejection apparatus that is used for any different usages than the printing of the image. The technique in the present disclosure may be applied to a liquid ejection apparatus that ejects a conductive liquid to a board to form a conductive pattern on the substrate, for example.

What is claimed is:

1. A liquid ejection apparatus comprising:

a pressure chamber;

a diaphragm covering the pressure chamber;

a metal film disposed onto the diaphragm;

a piezoelectric element having a piezoelectric component positioned opposing the pressure chamber;

a first electrode disposed on a first side of the piezoelectric component [toward the pressure chamber], *the first electrode being disposed over at least a portion of the metal film*;

a second electrode disposed on a second side of the piezoelectric component opposite *to* the first side in an opposed region, the opposed region being a region opposed to the second electrode*, the second side being opposite to the pressure chamber with respect to the first side*; and

[a] *wherein the* metal film [being] *is* absent from at least a portion of the opposed region;

wherein a portion of the metal film and a portion of the first electrode are in electrical contact with each other,

wherein the portion of the metal film and the portion of the first electrode are between the piezoelectric component and the diaphragm, *and*

wherein the piezoelectric component covers the portion of the metal film and the portion of the first electrode,

[wherein the first electrode is made of platinum and the metal film is made of a metal material other than platinum].

2. The liquid ejection apparatus according to claim **1**, wherein the metal film is disposed in a non-opposed region, the non-opposed region being outside of the opposed region.

3. The liquid ejection apparatus according to claim **1**, wherein the metal film is absent from the opposed region.

4. The liquid ejection apparatus according to claim **1**, wherein the metal film is thicker than the first electrode.

5. The liquid ejection apparatus according to claim **1**, wherein the portion of the metal film is disposed closer to the diaphragm than the first electrode is disposed to the diaphragm.

6. The liquid ejection apparatus according to claim **1**, wherein the metal film is disposed outside a region in which the diaphragm has maximum curvature of deformation.

7. The liquid ejection apparatus according to claim **1**, wherein the metal film constitutes a portion of a trace connected to the first electrode.

8. The liquid ejection apparatus according to claim **1**, wherein an entire surface of the metal film on a side opposite from the diaphragm is in direct contact with the first electrode.

9. The liquid ejection apparatus according to claim **1**, wherein the metal film is made of one of copper and aluminum.

10. The liquid ejection apparatus according to claim **1**, wherein the metal film is made of any one of zirconium, tantalum, and tungsten.

11. The liquid ejection apparatus according to claim **1**, wherein the first electrode has a thickness of 0.1 μm or less.

12. The liquid ejection apparatus according to claim **1**, further comprising:

a plurality of pressure chambers, each pressure chamber covered by the diaphragm; and

a plurality of piezoelectric elements.

13. The liquid ejection apparatus according to claim **12**,

wherein the plurality of piezoelectric elements form a first piezoelectric element row and a second piezoelectric element row, the first and second piezoelectric element rows each extending in a first direction and spaced apart from each other in a second direction perpendicular to the first direction; and

wherein the piezoelectric element is included in the second piezoelectric element row;

the liquid ejection apparatus further including a trace electrically connected to the metal film, the trace extending between adjacent piezoelectric elements of the plurality of piezoelectric elements in the first row, the trace at least partially exposed between the adjacent piezoelectric elements.

14. The liquid ejection apparatus according to claim **1**, further comprising a nozzle in fluid communication with the pressure chamber.

15. The liquid ejection apparatus according to claim 1, wherein the first electrode is made of platinum and the metal film is made of metal material other than platinum.

* * * * *